

Product Catalog

Wavelength-Tunable Sources

LIGHT CONVERSION is a global leader in ultrafast technology, designing and manufacturing femtosecond lasers, wavelength-tunable sources, optical parametric chirped-pulse amplifiers, spectroscopy systems, and microscopy sources.

The comprehensive portfolio represents the best-in-class lasers tailored for industry, science, and medicine.



10 000

Femtosecond laser systems installed worldwide



17 500

Square meters designated for manufacture and R&D

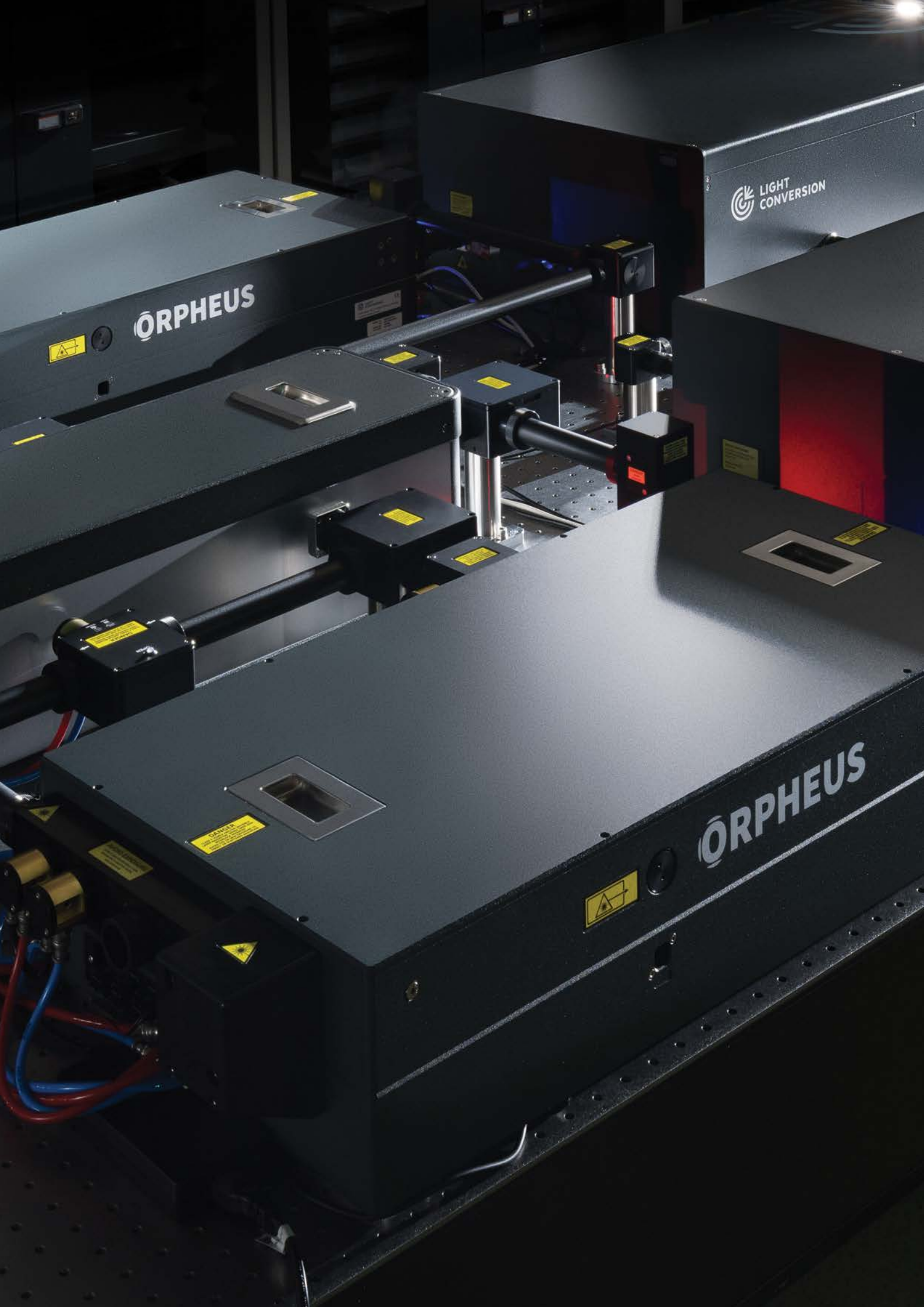


750

Employees, of whom 15% focus on R&D

About Us

Founded in 1994, LIGHT CONVERSION has evolved into a leading company in ultrafast laser technology with over 10 000 systems installed worldwide and 750 employees, 15% of whom focus on R&D. The company's lasers are used by all of the world's top 50 universities, highlighting its commitment to state-of-the-art research, while also ensuring the reliability and performance in 24/7 industrial applications. With international offices in the US, China, and Korea, along with a global representative network, the company ensures worldwide sales and service.



ORPHEUS

LIGHT
CONVERSION

ORPHEUS

Wavelength-Tunable Sources

Coupled with femtosecond lasers, these OPAs provide an invaluable source for ultrafast spectroscopy, nonlinear microscopy, and a variety of other scientific applications.

Continuous wavelength tunability from UV to MIR

Pulse durations from tens of femtoseconds to a few picoseconds

Leading OPA manufacturer for more than 30 years

I-OPA

The only industrial-grade commercial OPA, combining wavelength tunability with compact and robust design.

ORPHEUS

A classic OPA platform that many are familiar with – simple to use yet offers an extensive range of parameters.

ORPHEUS | NEO

Next-generation OPA featuring exceptional stability and multiple detectors for continuous power monitoring and diagnostics.

TOPAS

Classic OPAs for Ti:Sapphire lasers.

I-OPA

Industrial-Grade Optical Parametric Amplifier

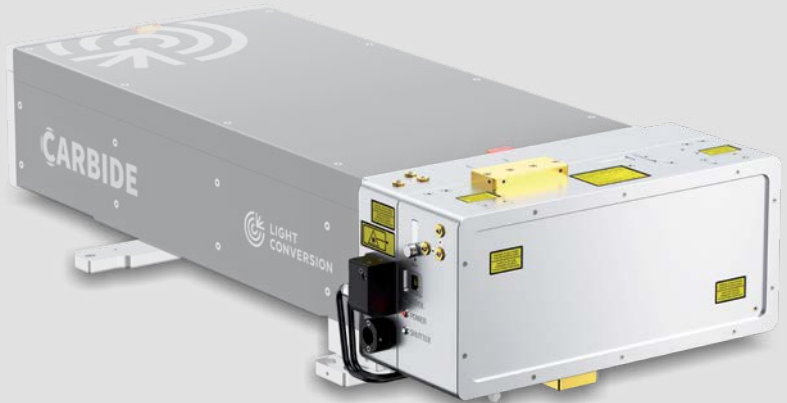
Wavelength tunability in an industrial design

Single-box solution

Tunable or fixed-wavelength models

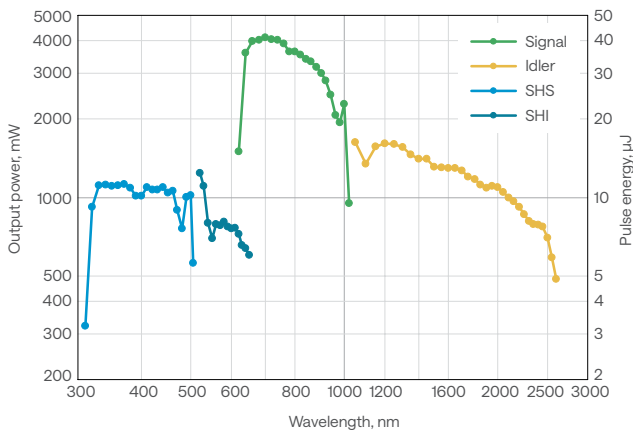
Plug-and-play installation and robust performance

The most compact OPA in the market

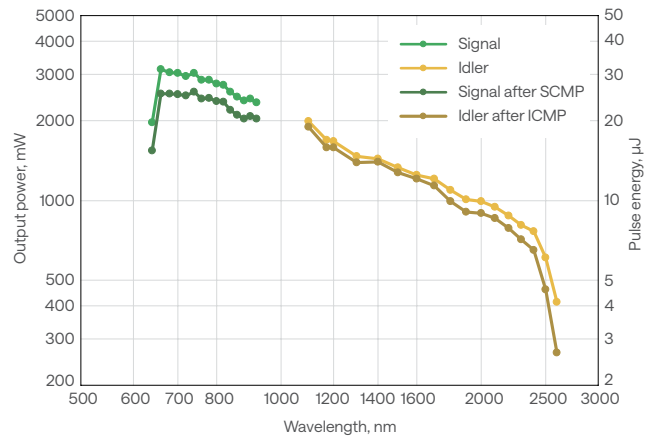


CARBIDE-CB3 with I-OPA-HP

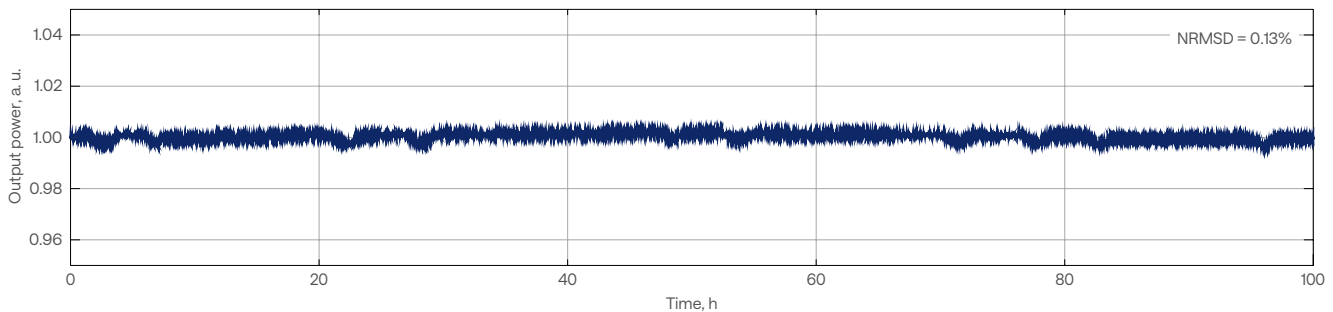
I-OPA-HP typical tuning curves
Pump: 40 W, 400 μ J, 100 kHz



I-OPA-F typical tuning curves
Pump: 40 W, 400 μ J, 100 kHz



I-OPA-HP
Typical power stability at 1300 nm



Specifications

| Model | I-OPA-HP | I-OPA-F | I-OPA-ONE |
|--|--|--|--|
| Configuration | ORPHEUS | ORPHEUS-F | ORPHEUS-ONE |
| Pump power | Up to 40 W | | |
| Pump pulse energy | 20 – 400 μ J | | |
| Repetition rate | Up to 2 MHz | | |
| Tuning range ¹⁾ | 640 – 1010 nm (signal) 1050 – 2600 nm (idler) | 650 – 920 nm (signal) 1200 – 2500 nm (idler) | 1350 – 2000 nm (signal) 2100 – 4500 nm (idler) |
| Conversion efficiency | > 7% @ 700 nm (40 – 400 μ J pump; up to 1 MHz) | | > 9% @ 1550 nm (40 – 400 μ J pump; up to 1 MHz) |
| | > 3.5% @ 700 nm (20 – 40 μ J pump; up to 2 MHz) | | > 6% @ 1550 nm (20 – 40 μ J pump; up to 2 MHz) |
| Spectral bandwidth ²⁾ | 80 – 220 cm^{-1} @ 700 – 960 nm | 200 – 1000 cm^{-1} @ 650 – 920 nm 150 – 1000 cm^{-1} @ 1200 – 2000 nm | 60 – 150 cm^{-1} @ 1450 – 2000 nm |
| Pulse duration ^{2) 3)} | 120 – 250 fs | < 55 fs @ 800 – 920 nm < 70 fs @ 650 – 800 nm < 100 fs @ 1200 – 2000 nm | 100 – 300 fs |
| Long-term power stability, 8 h ⁴⁾ | < 1% @ 800 nm | | < 1% @ 1550 nm |
| Pulse-to-pulse energy stability, 1 min ⁴⁾ | < 1% @ 800 nm | | < 1% @ 1550 nm |
| Wavelength extension options | 320 – 505 nm (SHS) ⁵⁾ 525 – 640 nm (SHI) ⁵⁾ | Contact sales@lightcon.com | 4500 – 10 000 nm (DFG) |
| Pulse compression options ²⁾ | n/a | SCMP (signal pulse compressor) ICMP (idler pulse compressor) | n/a |

PUMP LASER REQUIREMENTS

| | |
|-------------------------|-------------------|
| Pump laser | CARBIDE or PHAROS |
| Center wavelength | 1030 \pm 10 nm |
| Maximum pump power | 40 W |
| Maximum repetition rate | Up to 2 MHz |
| Pump pulse energy | 20 – 400 μ J |
| Pulse duration | 180 – 300 fs |

ENVIRONMENTAL & UTILITY REQUIREMENTS

Refer to lightcon.com

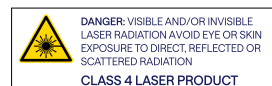
¹⁾ In the case of a fixed wavelength (FW), a single wavelength can be selected from the signal or idler range. The signal may have an accessible idler pair, and vice versa.

²⁾ I-OPA-F broad-bandwidth pulses are compressed externally. Typical pulse duration before compression: 120 – 250 fs, after compression: 25 – 70 fs @ 650 – 920 nm, 40 – 100 fs @ 1200 – 2000 nm.

³⁾ Output pulse duration depends on the selected wavelength and the pump laser pulse duration.

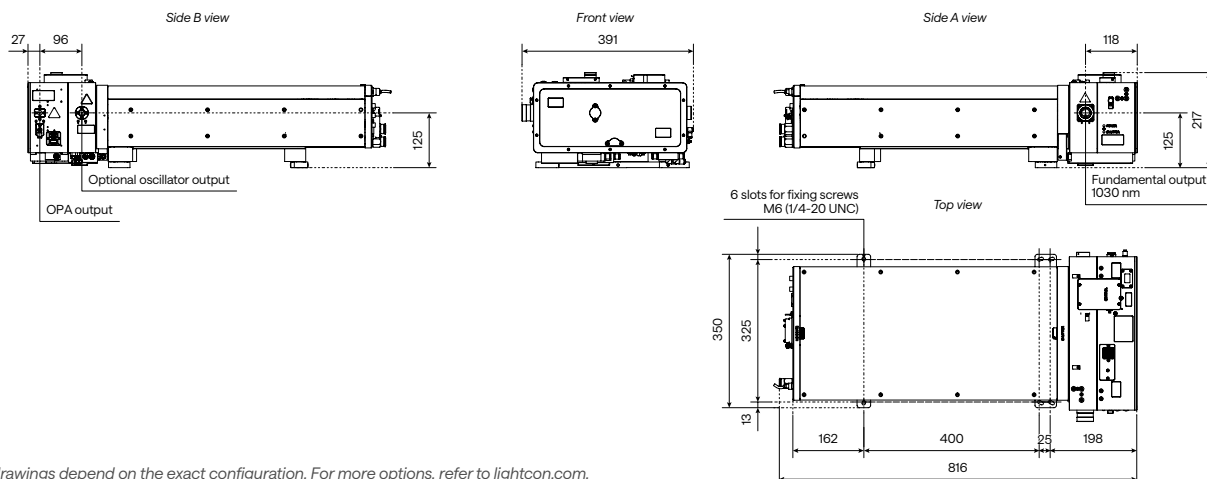
⁴⁾ Expressed as normalized root mean squared deviation (NRMSD).

⁵⁾ Conversion efficiency is 1.2% at peak; specified as a percentage of pump power.



Drawings

CARBIDE-CB3 with I-OPA-HP



The drawings depend on the exact configuration. For more options, refer to lightcon.com.



Optical Parametric Amplifier

Continuous tunability from UV to MIR, 190 – 16 000 nm

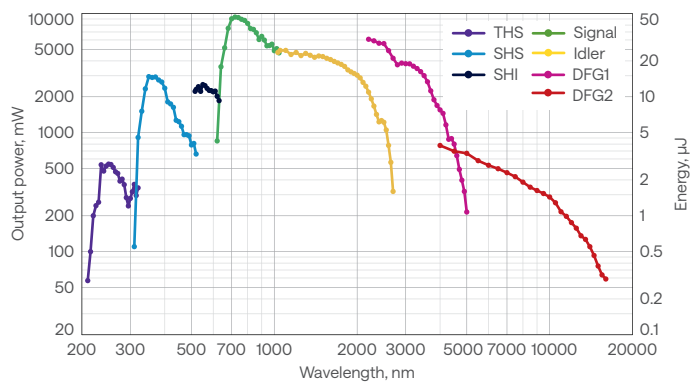
Single-shot – 2 MHz repetition rate

Up to 80 W pump power

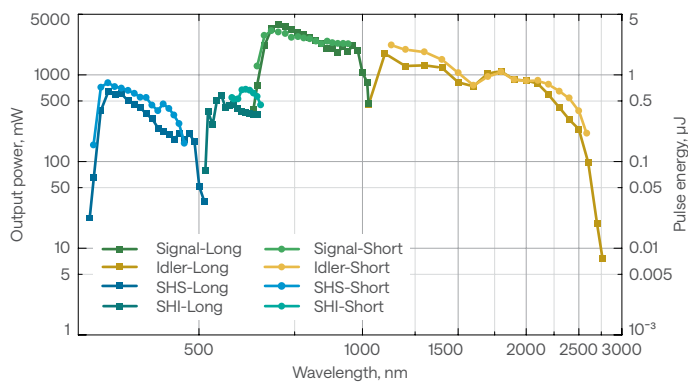
Up to 0.4 mJ pump pulse energy



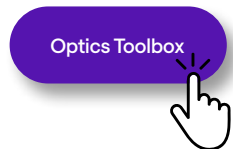
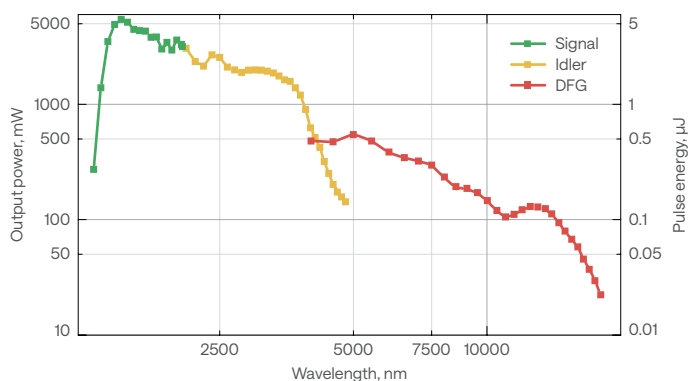
ORPHEUS typical tuning curves
Pump: 80 W, 400 μ J, 200 kHz



ORPHEUS-F typical tuning curves
Pump: 40 W, 40 μ J, 1000 kHz



ORPHEUS-ONE typical tuning curves
Pump: 40 W, 40 μ J, 1000 kHz



Specifications

| Model | ORPHEUS | | ORPHEUS-F | ORPHEUS-ONE |
|--|--|---|---|--|
| Tuning range ¹⁾ | 630 – 1030 nm (signal) 1030 – 2600 nm (idler) | | 650 – 900 nm (signal) 1200 – 2500 nm (idler) ²⁾ | 1400 – 2000 nm (signal) 2100 – 4200 nm (idler) |
| Pump power | Up to 80 W | | | |
| Repetition rate | Up to 2 MHz | | | |
| Pump pulse energy ³⁾ | 8 – 20 μJ | 20 – 400 μJ | 10 – 400 μJ | 12 – 400 μJ |
| Conversion efficiency | > 4.5% @ peak (signal) > 2% @ peak (idler) | > 9% @ peak (signal) > 4% @ peak (idler) | > 7% @ 700 nm ⁴⁾ | > 9%, 30 – 40 μJ pump @ 1550 nm > 6%, 12 – 30 μJ pump @ 1550 nm |
| Pulse duration | 120 – 400 fs | | < 55 fs @ 800 – 900 nm ⁵⁾ < 70 fs @ 650 – 800 nm ⁵⁾ < 100 fs @ 1200 – 2000 nm ⁵⁾ | 100 – 300 fs |
| Spectral bandwidth | 60 – 220 cm ⁻¹ | | 200 – 750 cm ⁻¹ @ 650 – 900 nm | 50 – 150 cm ⁻¹ @ 1450 – 2000 nm |
| Long-term power stability, 8 h ⁶⁾ | < 2% @ 800 nm | | | < 2% @ 1550 nm |
| Pulse-to-pulse energy stability, 1 min ⁶⁾ | < 2% @ 800 nm | | | < 2% @ 1550 nm |
| Compressor transmission | n/a | | 65% @ 650 – 900 nm 80% @ 1200 – 2000 nm | n/a |

WAVELENGTH EXTENSIONS

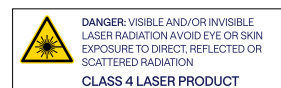
| | | | | |
|----------|--|--|--|---|
| DUV | n/a | 190 – 215 nm: > 0.3% @ 200 nm ⁷⁾ | n/a | n/a |
| THS | 210 – 315 nm: > 0.4% @ 250 nm ⁸⁾ | 210 – 315 nm: > 0.8% @ 250 nm ⁸⁾ | n/a | n/a |
| SHS, SHI | 315 – 630 nm: > 1.2% @ 350 nm | 315 – 630 nm: > 2.4% @ 350 nm | 325 – 450 nm: > 1% @ peak 600 – 650 nm: 0.5% @ peak | n/a |
| DFG | 2200 – 4200 nm: > 1.5% @ 3000 nm | 2200 – 4200 nm: > 3% @ 3000 nm | n/a | 4000 – 16 000 nm: > 0.3% @ 10 000 nm, 30 – 2000 μJ pump > 0.2% @ 10 000 nm, 12 – 30 μJ pump |
| | 4000 – 16 000 nm: > 0.1% @ 10 000 nm | 4000 – 16 000 nm: > 0.2% @ 10 000 nm | | |

PUPM LASER, ENVIRONMENTAL & UTILITY REQUIREMENTS

Refer to lightcon.com

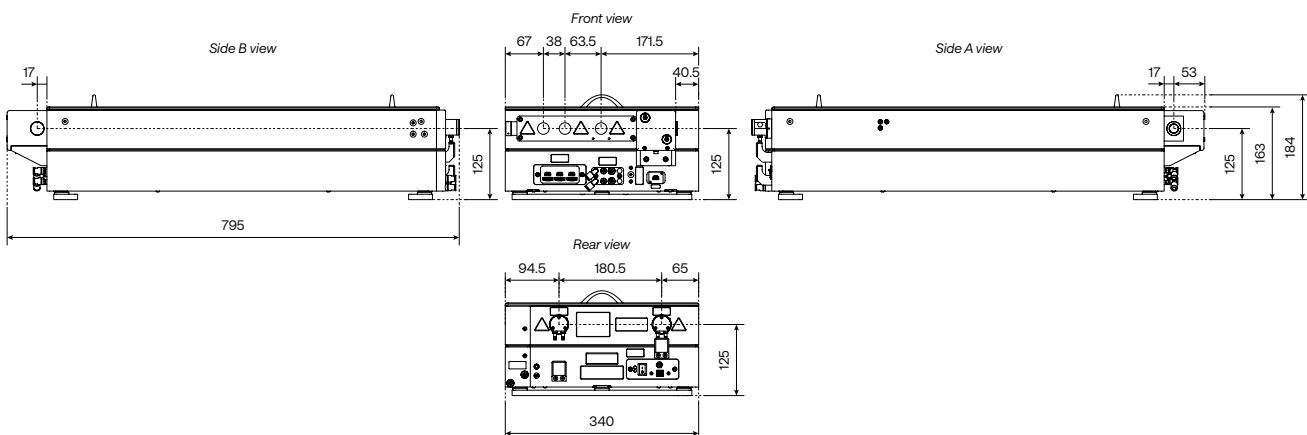
- ¹⁾ Dual output model (-TWINS) available, providing two optically synchronized and simultaneous outputs.
- ²⁾ Long pulse mode is optional, providing 650 – 1010 nm (signal) and 1050 – 2500 nm (idler) range at < 290 fs.
- ³⁾ Pump pulse energy up to 5 mJ applicable, refer to ORPHEUS-HE.
- ⁴⁾ Specified before pulse compressor. Conversion efficiency at peak is 10% for signal and idler combined.
- ⁵⁾ After pulse compression. Typical pulse duration before compression: 120 – 250 fs, after compression: 25 – 70 fs @ 650 – 920 nm, 40 – 100 fs @ 1200 – 2000 nm.

- ⁶⁾ Expressed as normalized root mean squared deviation (NRMSD).
- ⁷⁾ DUV conversion efficiency is specified for pump power up to 10 W and frequencies up to 200 kHz. In the case of higher pump power, conversion efficiency decreases. The maximum output power is 40 mW at 200 nm.
- ⁸⁾ For > 15 μJ pump pulse energy.



Drawings

ORPHEUS



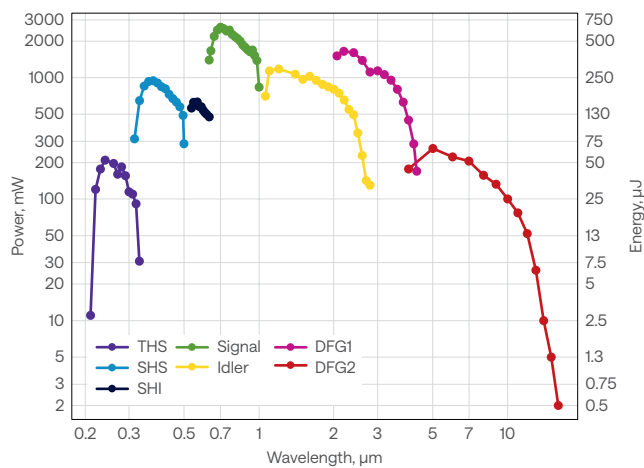
High-Energy Optical Parametric Amplifier

- NEW Up to 5 mJ pump pulse energy
- Continuous tunability from UV to MIR, 210 – 16 000 nm
- Up to 80 W pump power
- Single-shot – 200 kHz repetition rate

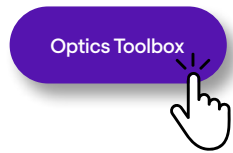
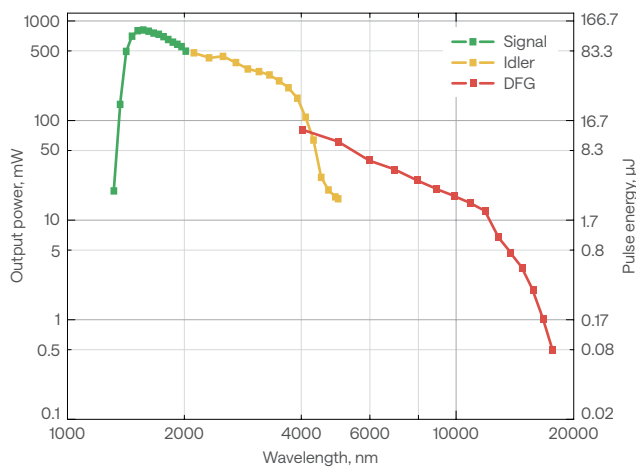


ORPHEUS-HE-5mJ

ORPHEUS-HE-5mJ typical tuning curves
Pump: 20 W, 5 mJ, 4 kHz



ORPHEUS-ONE-HE typical tuning curves
Pump: 6 W, 1 mJ, 6 kHz



Specifications

| Model | ORPHEUS-HE | ORPHEUS-HE-5mJ ¹⁾ | ORPHEUS-ONE-HE | ORPHEUS-ONE-HE-5mJ ¹⁾ |
|--|--|--|---|---|
| Pump pulse energy ²⁾ | 0.4 – 2 mJ | 2 – 5 mJ | 0.4 – 2 mJ | 2 – 5 mJ |
| Pump power | Up to 80 W | Up to 20 W | Up to 80 W | Up to 20 W |
| Tuning range | 630 – 1030 nm (signal) 1030 – 2600 nm (idler) | 630 – 1000 nm (signal) 1050 – 2600 nm (idler) | 1400 – 2000 nm (signal) 2100 – 4200 nm (idler) | 1400 – 2000 nm (signal) 2100 – 4500 nm (idler) |
| Conversion efficiency | > 8% @ 700 nm | | > 9% @ 1550 nm | |
| Spectral bandwidth | 60 – 220 cm ⁻¹ @ 700 – 960 nm | | 50 – 150 cm ⁻¹ @ 1450 – 2000 nm | |
| Pulse duration | 120 – 400 fs | | 100 – 400 fs | |
| Long-term power stability, 8 h ³⁾ | < 2% @ 800 nm | < 1% @ 800 nm | < 2% @ 1550 nm | < 1% @ 1550 nm |
| Pulse-to-pulse energy stability, 1 min ³⁾ | < 2% @ 800 nm | < 1% @ 800 nm | < 2% @ 1550 nm | < 1% @ 1550 nm |

WAVELENGTH EXTENSIONS

| | | | |
|----------|--|--|---|
| THS | 210 – 315 nm: > 0.8% @ 250 nm ⁴⁾ | 210 – 320 nm: > 0.4% @ 250 nm ⁴⁾ | n/a |
| SHS, SHI | 315 – 630 nm: > 2.4% @ 350 nm | 320 – 500 nm, 525 – 640 nm: > 2.4% @ 350 nm | n/a |
| DFG | 2200 – 4200 nm: > 3% @ 3000 nm | 2500 – 4200 nm: > 3% @ 3000 nm | 4000 – 16 000 nm: > 0.3% @ 10 000 nm |
| | 4000 – 16 000 nm: > 0.2% @ 10 000 nm | 4000 – 16 000 nm: > 0.2% @ 10 000 nm | |

PUMP LASER, ENVIRONMENTAL & UTILITY REQUIREMENTS

Refer to lightcon.com

¹⁾ Applicable only for PHAROS-5mJ.

²⁾ For lower pump pulse energy, refer to I-OPA, ORPHEUS, or ORPHEUS-NEO platforms.

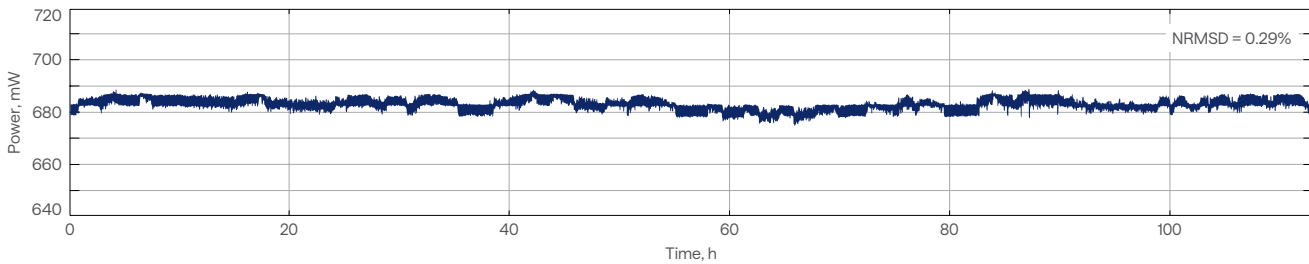
³⁾ Expressed as normalized root mean squared deviation (NRMSD).

⁴⁾ Maximum output power of 400 mW.



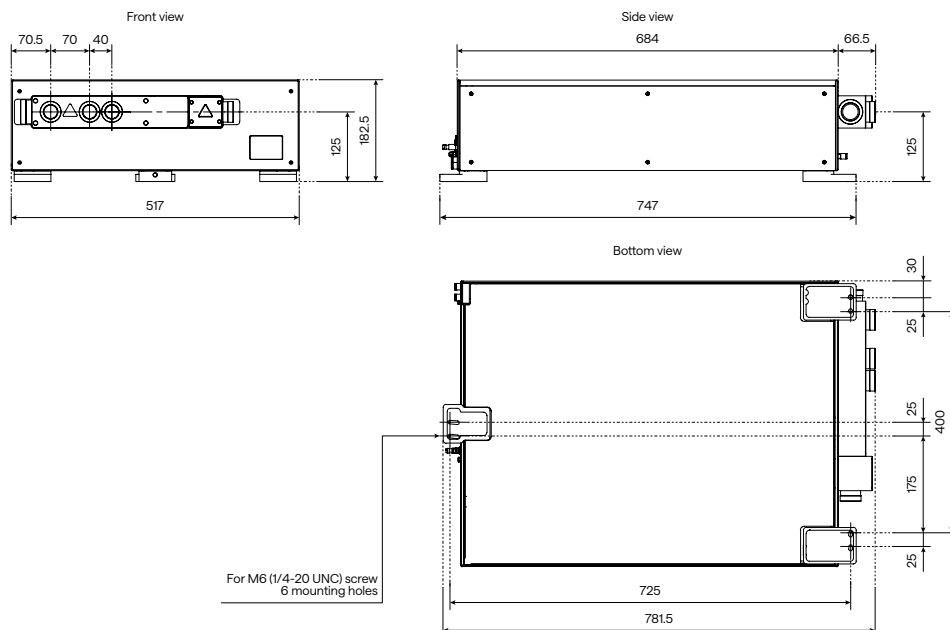
ORPHEUS-HE-5mJ

Long-term power stability at 400 nm



Drawings

ORPHEUS-HE-5mJ / -ONE-HE-5mJ



Next-Generation Optical Parametric Amplifier

Wavelength range from UV to MIR, 210 – 16 000 nm

Continuous power monitoring and diagnostics

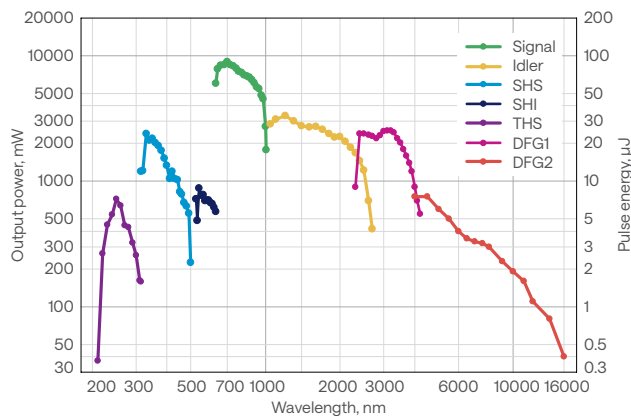
Pumped by PHAROS-UP for 100 fs pulses

Supports up to 80 W, 800 μ J pump at 2 MHz

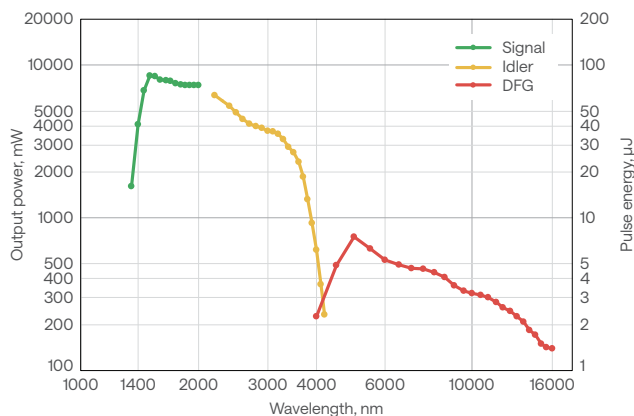
Fully integrated wavelength extensions



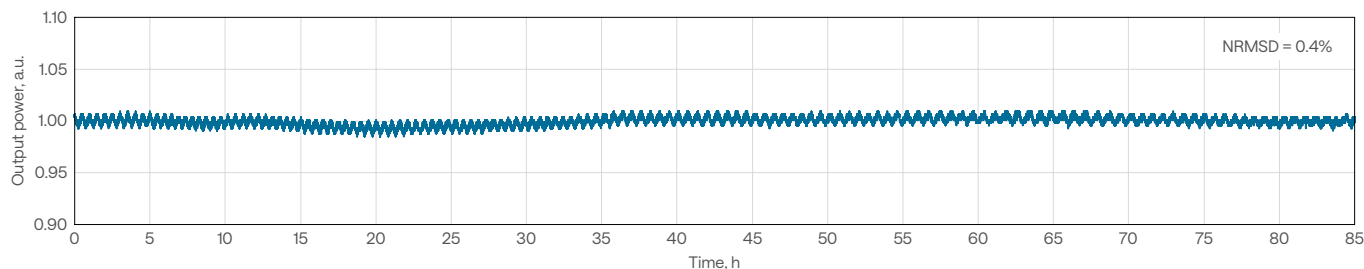
ORPHEUS-NEO typical tuning curves
Pump: 80 W, 800 μ J, 100 kHz



ORPHEUS-NEO-ONE typical tuning curves
Pump: 80 W, 800 μ J, 100 kHz



ORPHEUS-NEO typical long-term power stability at 800 nm



ORPHEUS-NEO specifications

| Model | ORPHEUS-NEO | ORPHEUS-NEO-ONE | ORPHEUS-NEO-UP | ORPHEUS-NEO-ONE-UP |
|--|---|---|---|---|
| Configuration | ORPHEUS | ORPHEUS-ONE | ORPHEUS | ORPHEUS-ONE |
| Pump laser | CARBIDE or PHAROS | | PHAROS-UP | |
| Pump power | Up to 80 W | | Up to 20 W | |
| Pump pulse energy | 20 – 800 μJ | | 20 – 400 μJ | |
| Repetition rate | Up to 2 MHz | | Up to 1 MHz | |
| Tuning range | 640 – 1000 nm (signal) 1050 – 2600 nm (idler) | 1400 – 2000 nm (signal) 2100 – 4200 nm (idler) | 640 – 1000 nm (signal) 1050 – 2600 nm (idler) | 1450 – 2000 nm (signal) 2100 – 4500 nm (idler) |
| Conversion efficiency | > 7% @ 700 nm (40 – 800 μJ pump; up to 1 MHz) | > 9% @ 1550 nm (40 – 800 μJ pump; up to 1 MHz) | > 7% @ 700 nm | > 9% @ 1550 nm |
| | > 3.5% @ 700 nm (20 – 40 μJ pump; up to 2 MHz) | > 6% @ 1550 nm (20 – 40 μJ pump; up to 2 MHz) | | |
| Spectral bandwidth | 60 – 220 cm ⁻¹ @ 700 – 960 nm | 50 – 150 cm ⁻¹ @ 1450 – 2000 nm | 120 – 300 cm ⁻¹ @ 700 – 2600 nm | 150 – 300 cm ⁻¹ @ 1500 – 1900 nm; 2200 – 3500 nm ¹⁾ |
| Pulse duration ²⁾ | 120 – 400 fs | 100 – 400 fs | < 110 fs @ 700 – 1000 nm < 120 fs @ 1060 – 2000 nm | < 120 fs @ 1500 – 1900 nm |
| Beam quality, M ² | < 1.3 @ 800 nm | < 1.3 @ 1550 nm | < 1.3 @ 800 nm | < 1.3 @ 1550 nm |
| Beam diameter ³⁾ | 2.1 ± 0.9 mm @ 800 nm | 2.1 ± 0.9 mm @ 1550 nm | 2.1 ± 0.9 mm @ 800 nm | 2.1 ± 0.9 mm @ 1550 nm |
| Beam divergence (full-angle) | < 2 mrad @ 800 nm | < 4 mrad @ 1550 nm | < 2 mrad @ 800 nm | < 4 mrad @ 1550 nm |
| Long-term power stability, 8 h ⁴⁾ | < 1% @ 800 nm | < 1% @ 1550 nm | < 1% @ 800 nm | < 1% @ 1550 nm |
| Pulse-to-pulse energy stability, 1 min ⁴⁾ | < 1% @ 800 nm | < 1% @ 1550 nm | < 1% @ 800 nm | < 1% @ 1550 nm |

WAVELENGTH EXTENSIONS

| | | | | |
|-----------------------|---|--|---|--|
| Conversion efficiency | 210 – 320 nm (THS) > 0.4% @ 250 nm | n/a | 210 – 320 nm (THS) 0.2% @ 250 nm | n/a |
| | 320 – 500 nm (SHS) and 525 – 640 nm (SHI) > 1.2% @ 350 nm | | 320 – 500 nm (SHS) and 525 – 640 nm (SHI) 1.2% @ 350 nm | |
| | n/a | 640 – 1000 nm and 1050 – 1350 nm > 1% @ 700 nm | n/a | 640 – 1000 nm and 1050 – 1450 nm (VIS-NIR) > 1% @ 700 nm |
| | 2500 – 4200 nm (DFG1) > 3% @ 3000 nm | 4000 – 16 000 nm (DFG) ⁵⁾ > 0.3% @ 10 000 nm (for > 40 μJ pump) | 2500 – 4500 nm (DFG1) 3% @ 3000 nm | 4500 – 14 000 nm (DFG) ⁵⁾ 0.2% @ 10 000 nm |
| | 4000 – 16 000 nm (DFG2) ⁵⁾ > 0.2% @ 10 000 nm | | 4500 – 14 000 nm (DFG2) ⁵⁾ 0.1% @ 10 000 nm | |

PUMP LASER, ENVIRONMENTAL & UTILITY REQUIREMENTS

Refer to lightcon.com

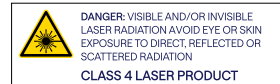
¹⁾ Spectral bandwidth is equal to 150 – 250 cm⁻¹ @ 5000 – 12 000 nm.

²⁾ Output pulse duration depends on the selected wavelength and the pump laser pulse duration.

³⁾ FW 1/e², measured at laser output, using maximum pulse energy.

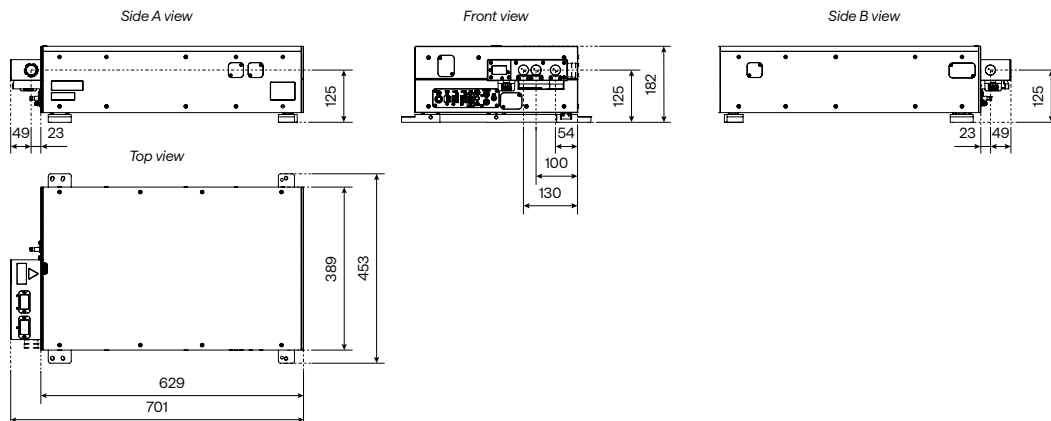
⁴⁾ Expressed as normalized root mean squared deviation (NRMSD).

⁵⁾ Pre-installed output window limits the tuning range to 12 μm. The window is used for dust protection and output power diagnostics, but it can be removed to access the full wavelength range.



Drawings

ORPHEUS-NEO / ORPHEUS-NEO-UP



Broad-Bandwidth MIR Optical Parametric Amplifier

Broad-bandwidth MIR pulses
at high repetition rates

Continuously tunable from
2500 to 15 000 nm

Pumped by industrial-grade
lasers for high stability

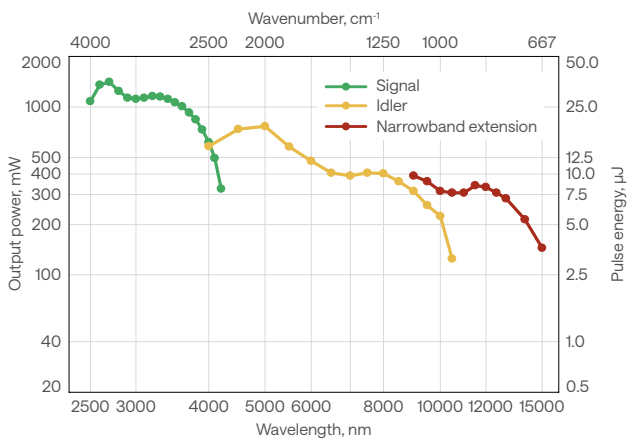
CEP-stable option

NEW

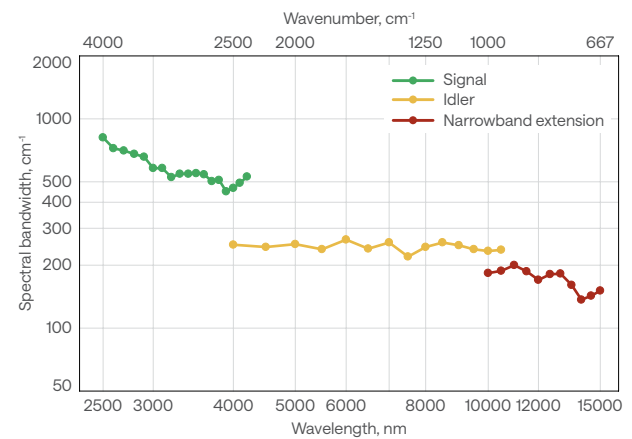
New housing for high output stability



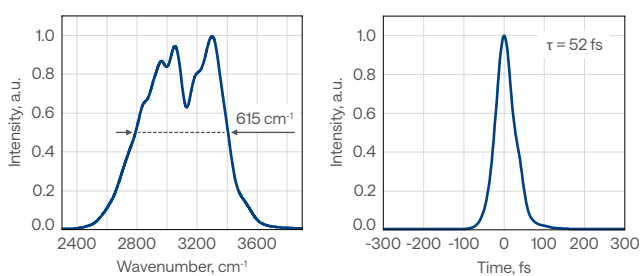
ORPHEUS-MIR typical tuning curves
Pump: 80 W, 2 mJ, 40 kHz



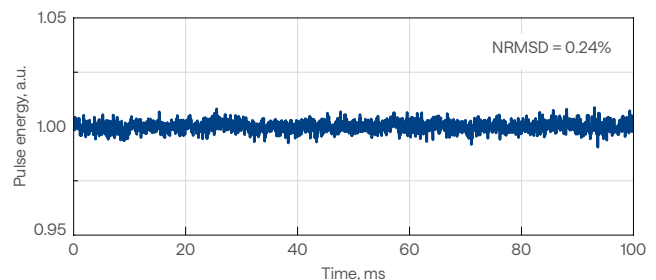
ORPHEUS-MIR typical spectral bandwidth



ORPHEUS-MIR typical output spectrum (left) and
pulse duration (right) measured at ≈ 3000 nm



ORPHEUS-MIR pulse-to-pulse energy stability
measured at ≈ 3000 nm



Specifications

MAIN OUTPUT (2500 – 10 000 nm)

| Mode of operation | Non-collinear | Collinear ¹⁾ |
|--|--|---|
| Tuning range | 2500 – 4000 nm (signal) 4000 – 10 000 nm (idler) | 2500 – 4500 nm (signal) ²⁾ 4500 – 10 000 nm (idler) |
| Maximum pump power | 80 W | |
| Pump pulse energy | 200 μJ – 3 mJ | |
| Maximum repetition rate | 100 kHz | |
| Pulse duration | < 100 fs | < 400 fs (< 100 fs with dispersion compensation) ¹⁾ |
| Conversion efficiency ³⁾ | > 1.2% @ 3000 nm > 1.0% @ 3500 nm > 0.6% @ 5000 nm > 0.3% @ 9000 nm | |
| Spectral bandwidth ⁴⁾ | > 300 cm ⁻¹ @ 3000 – 4000 nm > 200 cm ⁻¹ @ 4000 – 10 000 nm | |
| Long-term power stability, 8 h ⁵⁾ | < 2% @ 5000 nm | |
| Pulse-to-pulse energy stability, 1 min ⁵⁾ | < 2% @ 5000 nm | |

AUXILIARY OUTPUT (2000 nm)

| | |
|-------------------------------------|------------------------|
| Output wavelength ⁶⁾ | 2000 ± 100 nm |
| Pulse duration | < 50 fs |
| Conversion efficiency ³⁾ | > 8% |
| Spectral bandwidth | > 350 cm ⁻¹ |

WAVELENGTH EXTENSION (10 000 – 15 000 nm)

| | | |
|-------------------------------------|------------------------|-----|
| Tuning range | 10 000 – 15 000 nm | n/a |
| Conversion efficiency ³⁾ | > 0.2% @ 12 000 nm | |
| Spectral bandwidth | > 100 cm ⁻¹ | |

PUMP LASER, ENVIRONMENTAL & UTILITY REQUIREMENTS

Refer to lightcon.com

¹⁾ Collinear mode is achieved with an additional external separator box. Dispersion compensation is optional.

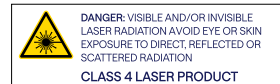
²⁾ Signal output is realized in non-collinear configuration.

³⁾ Specified as a percentage of pump power.

⁴⁾ Full width at half maximum (FWHM).

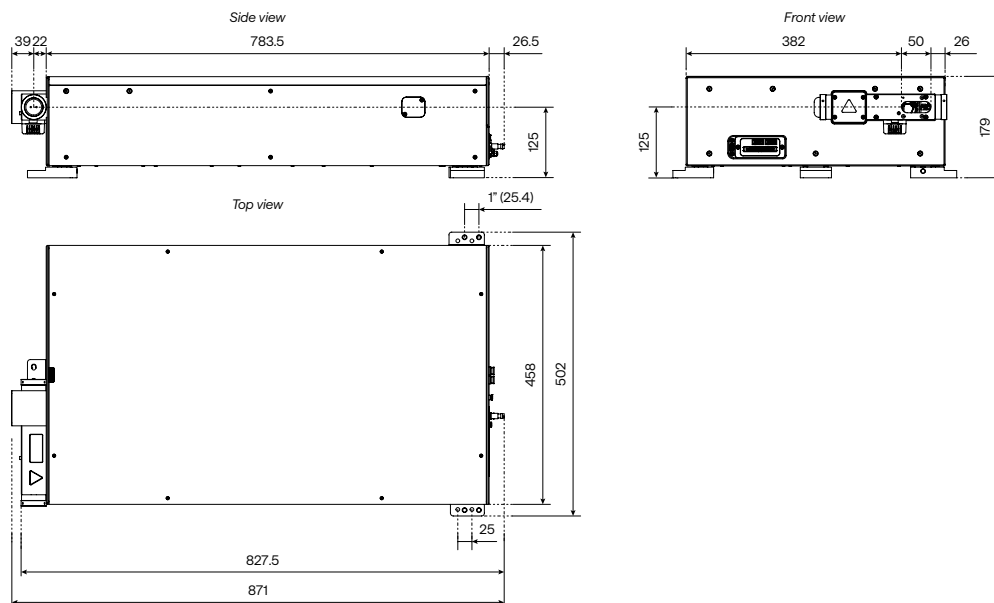
⁵⁾ Expressed as normalized root mean squared deviation (NRMSD).

⁶⁾ Not tunable, optimized for best overall performance. Not simultaneous to OPA output.



Drawings

ORPHEUS-MIR



Broad-Bandwidth VIS Optical Parametric Amplifier

Ultrashort UV – VIS – NIR pulses

< 50 fs pulse duration at 500 nm

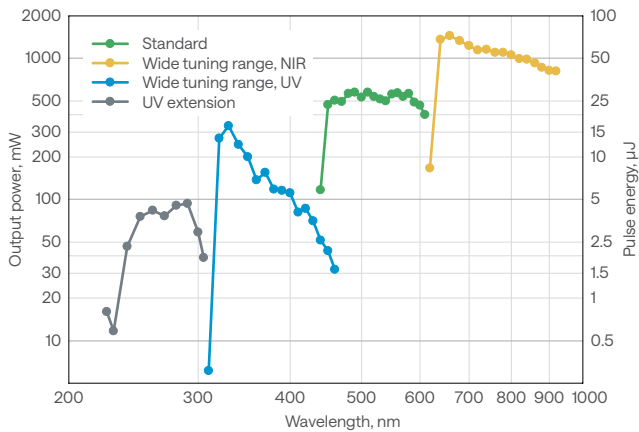
Up to 100 kHz repetition rate

Up to 20 W, 1 mJ pump

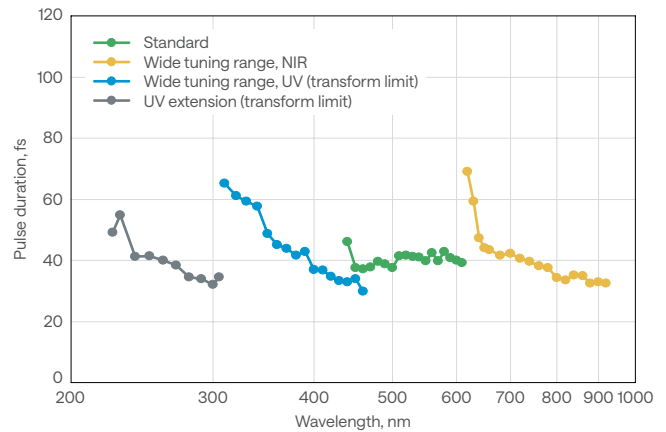
Optional UV extension down to 250 nm



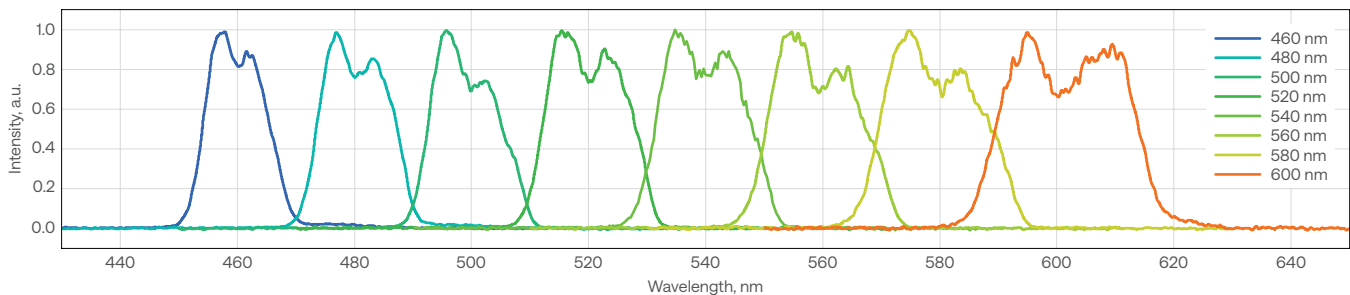
ORPHEUS-VIS tuning curves
Pump: 20 W, 1 mJ



ORPHEUS-VIS typical pulse duration



ORPHEUS-VIS standard configuration's typical spectra set



Specifications

MAIN OUTPUT

| | | |
|--|----------------------------|--|
| Configuration | Standard | Wide tuning range |
| Tuning range | 450 – 600 nm | 320 – 900 nm |
| Maximum pump power | 20 W | |
| Pump pulse energy | 200 – 1000 μ J | |
| Conversion efficiency ¹⁾ | > 1.5% @ 500 nm | > 1.5% @ 500 nm > 5.0% @ 660 nm > 0.5% @ 350 nm |
| Pulse duration | < 50 fs @ 500 – 600 nm | < 50 fs @ 500 – 600 nm < 55 fs @ 800 – 900 nm < 70 fs @ 650 – 800 nm |
| Spectral bandwidth ²⁾ | 200 – 700 cm^{-1} | |
| Long-term power stability, 8 h ³⁾ | < 2% @ 500 nm | |

OPTIONAL EXTENSION (UV)

| | |
|-------------------------------------|----------------------------|
| Tuning range | 250 – 300 nm |
| Conversion efficiency ¹⁾ | > 0.15% @ 280 nm |
| Spectral bandwidth ²⁾ | 200 – 600 cm^{-1} |

PUMP LASER REQUIREMENTS

| | |
|-----------------------------------|--------------------|
| Pump laser | CARBIDE or PHAROS |
| Center wavelength | 1030 \pm 10 nm |
| Maximum pump power | 20 W |
| Maximum repetition rate | 100 kHz |
| Pump pulse energy | 200 – 1000 μ J |
| Pump pulse duration ⁴⁾ | 200 – 350 fs |

ENVIRONMENTAL & UTILITY REQUIREMENTS

| | |
|-------------------------------------|--|
| Operating temperature ⁵⁾ | 19 – 25 $^{\circ}$ C (air conditioning recommended) |
| Relative humidity ⁵⁾ | 20 – 70% (non-condensing) |
| Electrical requirements | 100 – 240 V AC, 1.4 A; 50 – 60 Hz |
| Rated power | 120 W |
| Power consumption | Standby: 10 W Max during wavelength tuning: 100 W |

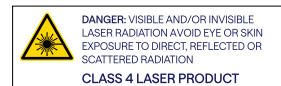
¹⁾ Specified as a percentage of pump power.

²⁾ Full width at half maximum (FWHM).

³⁾ Expressed as normalized root mean squared deviation (NRMSD).

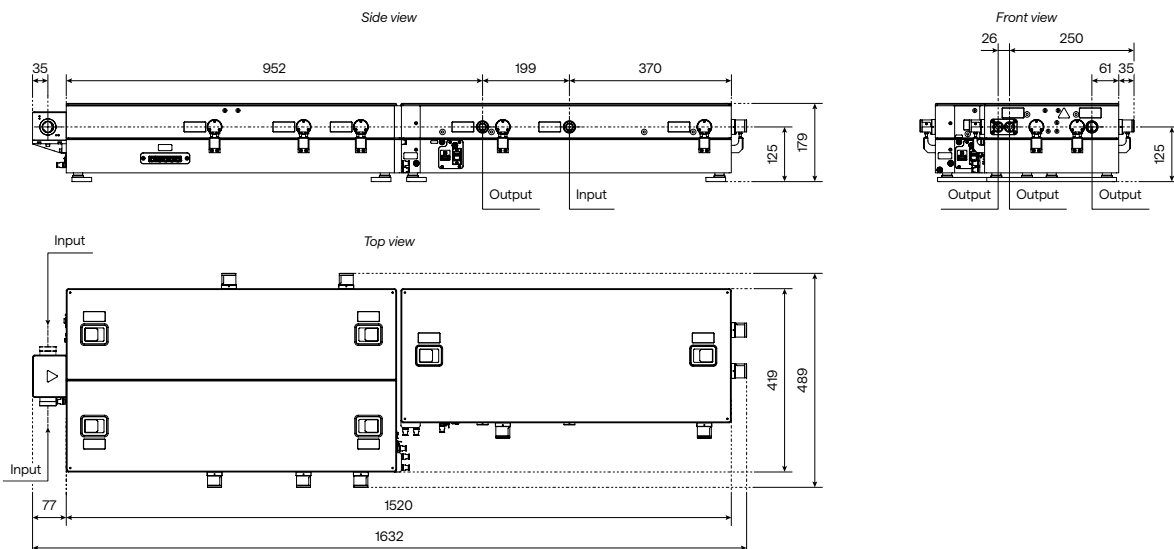
⁴⁾ Full width at half maximum (FWHM), assuming a Gaussian pulse shape.

⁵⁾ Specifications are guaranteed for a maximum temperature variation of $\pm 1^{\circ}$ C and humidity variation of $\pm 10\%$.



Drawings

ORPHEUS-VIS



Non-Collinear Optical Parametric Amplifier

Pulse duration down to < 30 fs

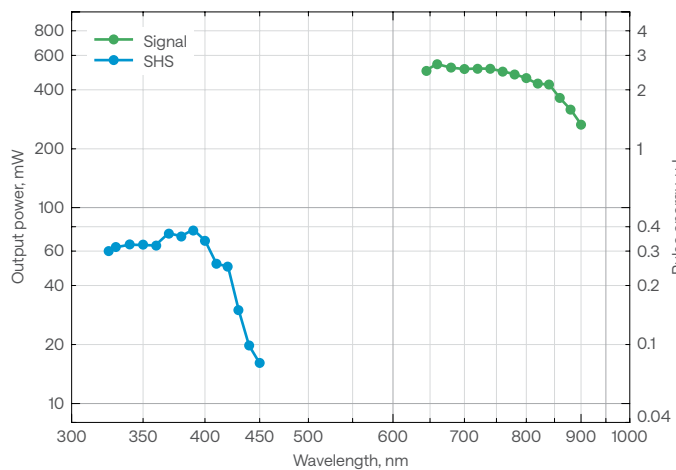
Integrated prism compressor

Adjustable spectral bandwidth and pulse duration

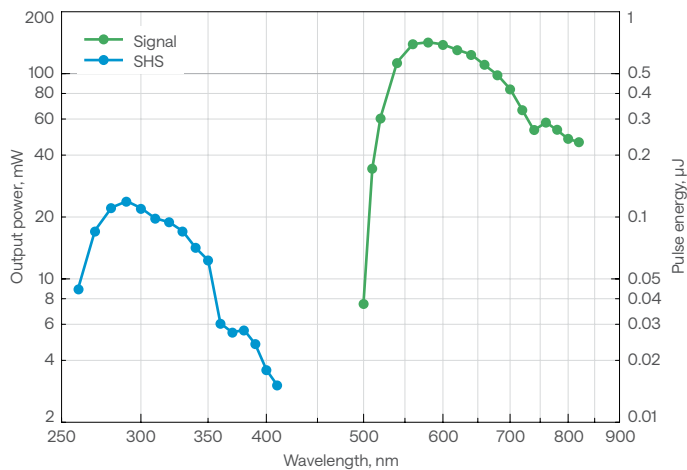
Wavelength feedback with an internal spectrometer



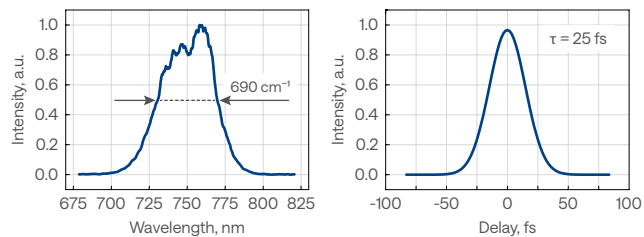
ORPHEUS-N-2H typical tuning curves
Pump: 6 W, 30 μ J, 200 kHz



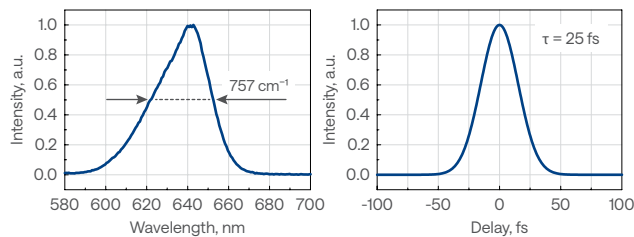
ORPHEUS-N-3H typical tuning curves
Pump: 6 W, 30 μ J, 200 kHz



ORPHEUS-N-2H typical output



ORPHEUS-N-3H typical output



Specifications

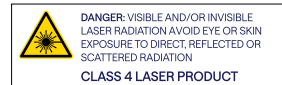
| Model | ORPHEUS-N-2H | ORPHEUS-N-3H |
|--|--|---|
| MAIN OUTPUT | | |
| Tuning range | 650 – 900 nm (signal) | 520 – 900 nm (signal) |
| Maximum pump power | 8 W | |
| Pump pulse energy | 10 – 200 μ J | 12 – 200 μ J |
| Conversion efficiency | > 7% @ 700 nm > 5% @ 800 nm | > 1.3% @ 580 nm > 0.7% @ 700 nm > 0.3% @ 800 nm |
| Integrated 2H / 3H generation efficiency ¹⁾ | > 35% (515 nm) | > 25% (343 nm) |
| Pulse duration after compressor | < 30 fs @ 700 – 850 nm | < 30 fs @ 540 – 660 nm < 70 fs @ 660 – 800 nm |
| Long-term power stability, 8 h ²⁾ | < 2% @ 800 nm | < 2% @ 580 nm |
| Pulse-to-pulse energy stability, 1 min ²⁾ | < 2% @ 800 nm | < 2% @ 580 nm |
| WAVELENGTH EXTENSIONS | | |
| Tuning range (SHS) | 325 – 450 nm | 260 – 450 nm |
| Conversion efficiency | > 0.7% @ 350 nm | > 0.15% @ 290 nm |
| PUMP LASER REQUIREMENTS | | |
| Pump laser | CARBIDE or PHAROS | |
| Center wavelength | 1030 \pm 10 nm | |
| Maximum pump power | 8 W | |
| Repetition rate | Single-shot – 800 kHz | Single-shot – 600 kHz |
| Pump pulse energy | 10 – 200 μ J | 12 – 200 μ J |
| Pump pulse duration ³⁾ | 180 – 500 fs | |
| ENVIRONMENTAL & UTILITY REQUIREMENTS | | |
| Operating temperature ⁴⁾ | 19 – 25 °C (air conditioning recommended) | |
| Relative humidity ⁴⁾ | 20 – 70% (non-condensing) | |
| Electrical requirements | 100 – 240 V AC, 1.4 A; 50 – 60 Hz | |
| Rated power | 120 W | |
| Power consumption | Standby: 10 W Max during wavelength tuning: 100 W | |
| Purging requirements | Nitrogen purge – optional | Nitrogen purge – required, 1 – 3 liters per minute |

¹⁾ Not simultaneous to NOPA output.

²⁾ Expressed as normalized root mean squared deviation (NRMSD).

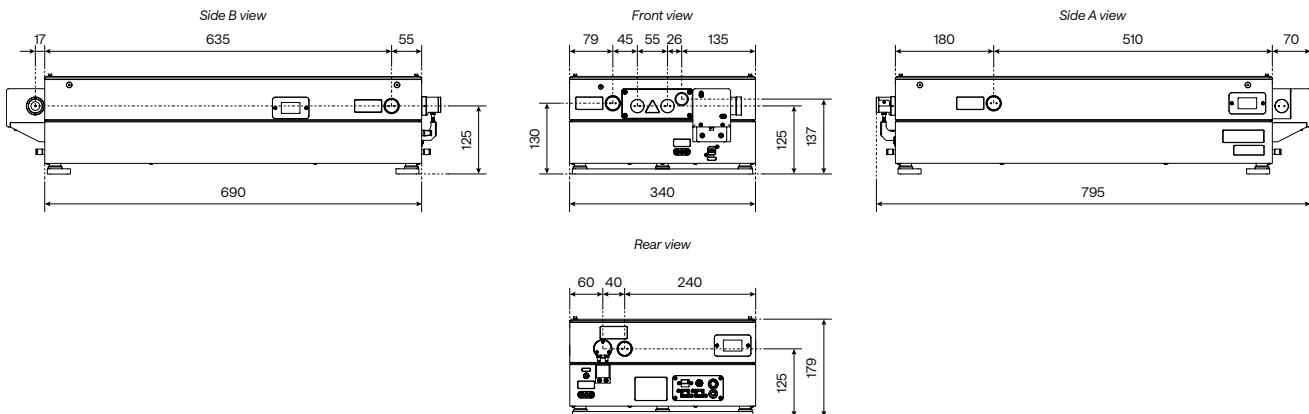
³⁾ Full width at half maximum (FWHM), assuming a Gaussian pulse shape.

⁴⁾ Specifications are guaranteed for a maximum temperature variation of \pm 1°C and humidity variation of \pm 10%.



Drawings

ORPHEUS-N



Narrow-Bandwidth Optical Parametric Amplifier

Picosecond pulses from a femtosecond pump

210 – 4800 nm tuning range

800 fs – 3 ps pulse duration

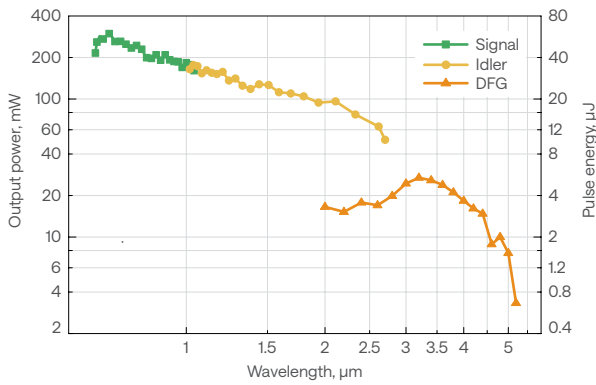
< 20 cm⁻¹ spectral bandwidth

Up to 100 kHz repetition rate

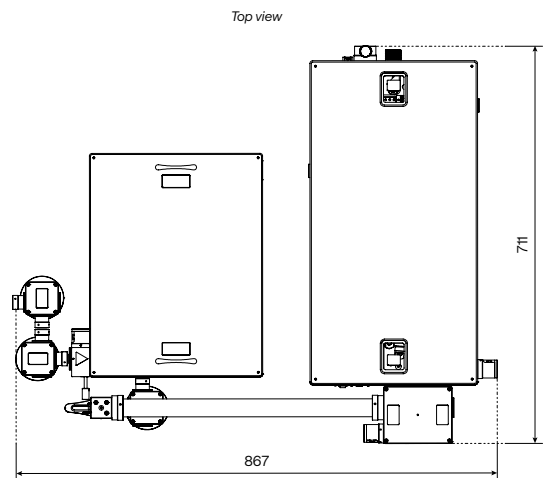


ORPHEUS-PS tuning curves

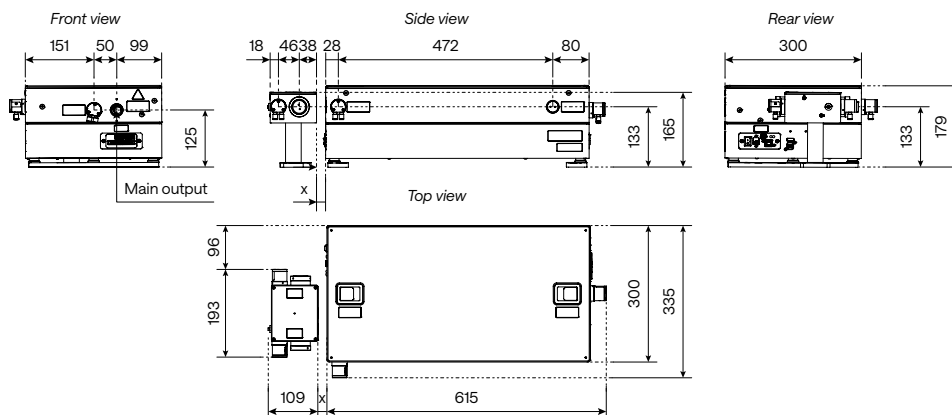
Pump: 5 W, 1000 μJ, 5 kHz from PHAROS-20W-SP



ORPHEUS-PS with SHBC drawing



ORPHEUS-PS drawing



Specifications

MAIN OUTPUT

| | |
|---|--|
| Tuning range ¹⁾ | 640 – 1000 nm (signal) 1060 – 2600 nm (idler) |
| Conversion efficiency | > 6% @ 700 nm |
| Pulse duration | 800 fs – 3 ps |
| Spectral bandwidth | < 20 cm ⁻¹ @ 800 nm |
| Pulse-to-pulse energy stability ²⁾ | < 2% @ 800 nm |

AUXILIARY OUTPUT 1 (515 nm)

| | |
|-------------------------------------|---------------|
| Center wavelength ³⁾ | 515 nm ± 5 nm |
| Generation efficiency ⁴⁾ | > 15% |

AUXILIARY OUTPUT 2 (1030 nm)

| | |
|---------------------------------|--------------|
| Center wavelength ⁵⁾ | 1030 ± 10 nm |
| Pulse duration | < 300 fs |
| Pulse energy | > 5 µJ |

WAVELENGTH EXTENSION

| | |
|----------|--|
| SHS, SHI | 320 – 500 nm, 530 – 640 nm: > 3% @ 350 nm |
| FHS, FHI | 210 – 250 nm, 265 – 320 nm: > 0.3% @ 230 nm |
| DFG | 2400 – 4800 nm: contact sales@lightcon.com |

PUMP LASER REQUIREMENTS

| | |
|--------------------------|---|
| Pump laser ⁶⁾ | CARBIDE or PHAROS with uncompressed output option ⁷⁾ |
| Center wavelength | 1030 ± 10 nm |
| Repetition rate | Single-shot – 100 kHz |
| Maximum pump power | 20 W |
| Pump pulse energy | 100 µJ – 3.2 mJ |

ENVIRONMENTAL & UTILITY REQUIREMENTS

| | |
|-------------------------------------|--|
| Operating temperature ⁸⁾ | 19 – 25 °C (air conditioning recommended) |
| Relative humidity ⁸⁾ | 20 – 70% (non-condensing) |
| Electrical requirements | 100 – 240 V AC, 1.4 A; 50 – 60 Hz |
| Rated power | 120 W |
| Power consumption | Standby: 10 W Max during wavelength tuning: 100 W |

¹⁾ For a single wavelength (515 nm) picosecond output, refer to SHBC.

²⁾ Expressed as normalized root mean squared deviation (NRMSD)

³⁾ Direct SHBC output, not simultaneous to OPA; see more details in SHBC specifications.

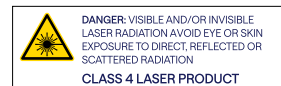
⁴⁾ Specified as a percentage of pump pulse energy.

⁵⁾ Compressed pump output.

⁶⁾ The pump laser is first paired with the SHBC module, then the SHBC output is used to pump the OPA. The parameter requirements are for the pump laser.

⁷⁾ Not compatible with PHAROS-PH2-UP.

⁸⁾ Specifications are guaranteed for a maximum temperature variation of ± 1 °C and humidity variation of ± 10%.



Optical Parametric Amplifiers for Ti:Sapphire Lasers

Tuning range 1160 – 2600 nm,
extendable to 189 nm – 20 μm

Conversion efficiency of > 25%

Wavelength extensions and
high-energy upgrades

Nearly bandwidth- and
diffraction-limited output

CEP stabilization of idler, 1600 – 2600 nm



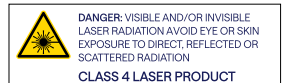
Comparison table

| Product ¹⁾ | Pump pulse energy ²⁾ | Tuning range | Extended tuning range | Output pulse duration | Upgrades | Features |
|---------------------------|---------------------------------|----------------|---------------------------|-----------------------|----------|---|
| TOPAS-PRIME | 0.15 – 6 mJ | 1160 – 2600 nm | 189 nm – 20 μm | 30 – 150 fs | HE-STAGE | Motorized wavelength control, hands-free operation |
| TOPAS-PRIME-HE | 2 – 60 mJ | | | | n/a | High energy, high conversion efficiency |
| TOPAS-TWINS ³⁾ | 0.3 – 6 mJ | | | | HE-STAGE | Two independently tunable CEP-stable outputs |

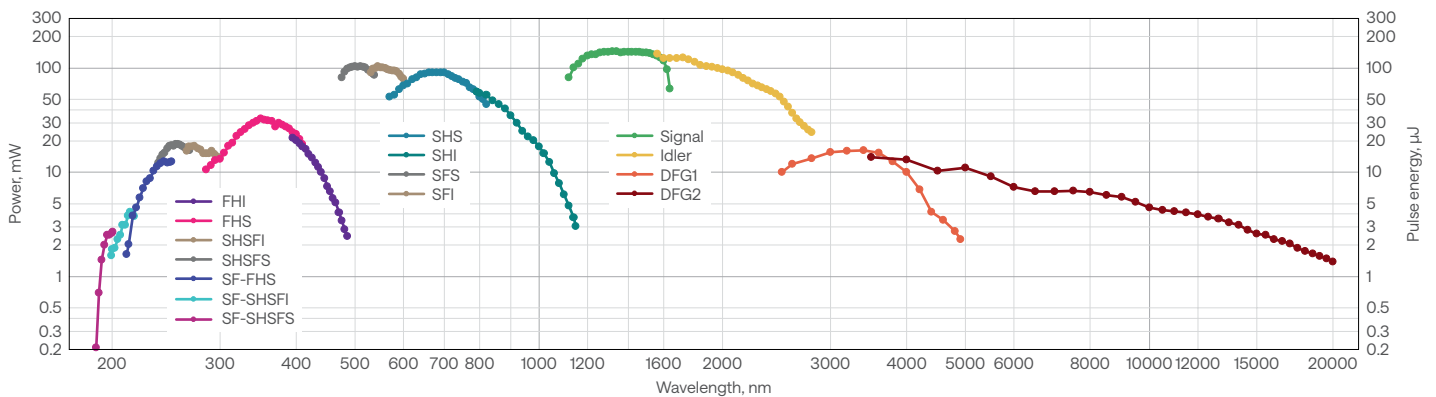
¹⁾ Custom solutions are available, contact sales@lightcon.com for more details.

²⁾ Maximum pump pulse energy depends on pump pulse duration.

³⁾ TWINS consists of two OPAs, seeded by the same white light source. Specifications and upgrades are applicable for each output.



TOPAS-PRIME tuning curves. Pump: 1 mJ, 100 fs, 800 nm



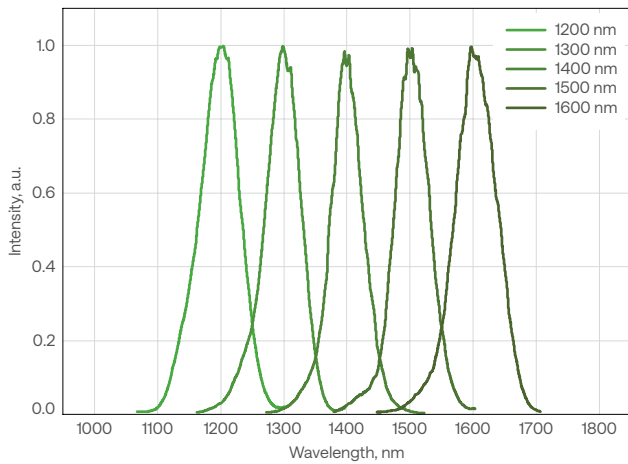
Wavelength extensions and upgrades

| Product | Tuning range | Features |
|----------------|----------------------|--|
| HE-STAGE | 1160 – 2600 nm | High-energy upgrade for TOPAS-PRIME or TOPAS-TWINS |
| NIRUVIS | 240 – 2600 nm | Motorized wavelength tuning, single housing |
| NIRUVIS-DUV-HE | 189 – 2600 nm | High-energy version, broadest tuning range, motorized wavelength tuning, single housing |
| NIRUVIS-DUV | 189 – 2600 nm | Broadest tuning range, motorized wavelength tuning, single housing |
| NIRUVIS-MW | 240 – 2600 nm | Fully automated version, the same output port for the entire wavelength range, motorized wavelength tuning, single housing |
| NDFG | 2600 nm – 20 μ m | Noncolinear generator for background-free mid-IR pulses |
| SIG-SIG NDFG | 4500 nm – 16 μ m | Noncolinear generator for CEP-stable mid-IR pulses used with TOPAS-TWINS, CEP slow drift compensation-ready ¹⁾ |

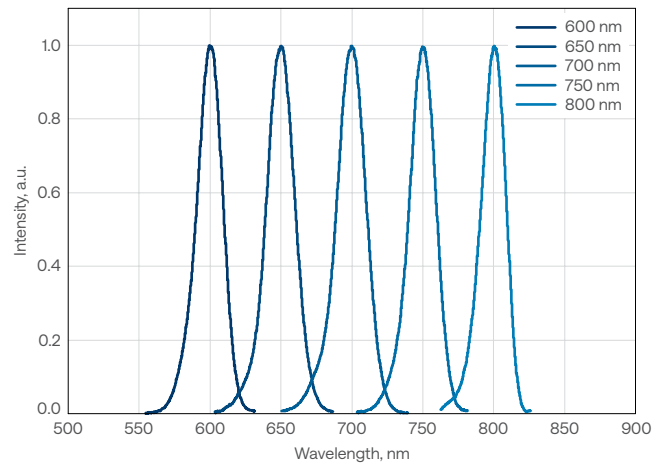
¹⁾ CEP slow drift is available upon request.

Performance

TOPAS-PRIME typical signal spectra set



TOPAS-PRIME SHS typical signal spectra set

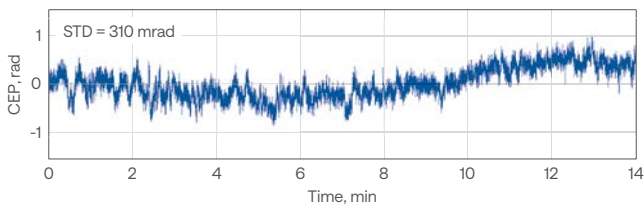


CEP stabilization of idler

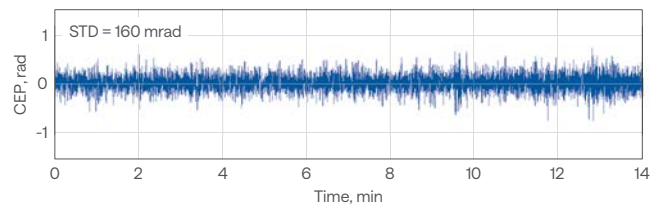
TOPAS idler (1600 – 2600 nm) is passively CEP locked due to a three-wave interaction. However, a slow CEP drift may persist because of changes in pump beam pointing or environmental conditions.

Such a drift can be compensated by employing an f-2f interferometer and a feedback loop controlling the temporal delay between the seed and pump in the power amplification stage of TOPAS-PRIME and TOPAS-PRIME-HE.

CEP stability of idler over 14 min
(a) without drift compensation



(b) with drift compensation with a slow loop



Femtosecond Lasers

LIGHT CONVERSION is world-renowned for its industrial-grade Yb-based femtosecond lasers, covering a wide range of industrial, scientific, and medical applications.

High average power and pulse energy at high repetition rates

Market-proven industrial-grade stability and reliability

Automated harmonics and wavelength-tunable extensions

CARBIDE

Compact industrial design in air- or water-cooled models, providing up to 120 W, 1 mJ or 80 W, 2 mJ with excellent output stability.

PHAROS

Scientific flexibility with process-tailored output parameters, offering up to 1 mJ pulse energy at < 100 fs or up to 5 mJ at < 250 fs.

Industrial Femtosecond Lasers

Maximum output of 120 W (IR)
or 50 W (UV)

NEW

Single-shot – 10 MHz repetition rate

Pulse-on-demand and
BiBurst for pulse control

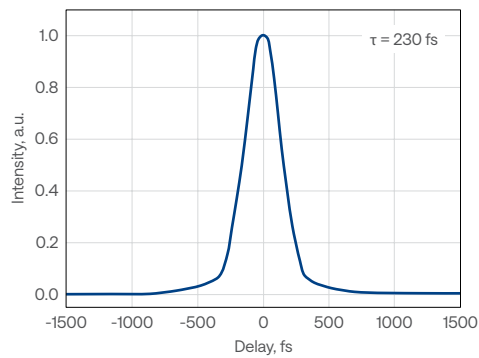
Automated harmonics up to the 5th
and wavelength-tunable extensions

Air-cooled or water-cooled models

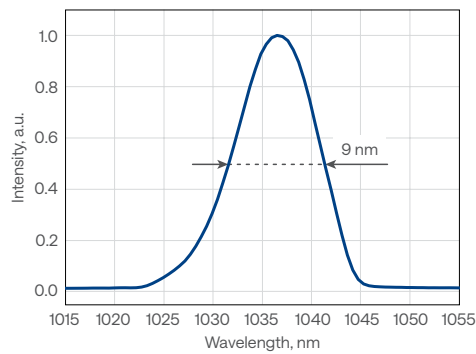


CARBIDE-CB3

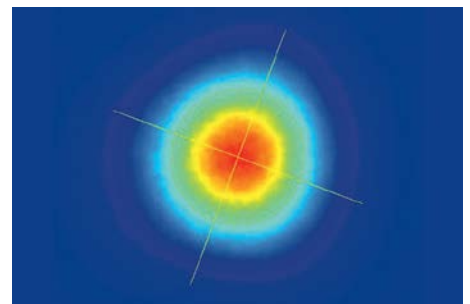
CARBIDE-CB3
Typical pulse duration



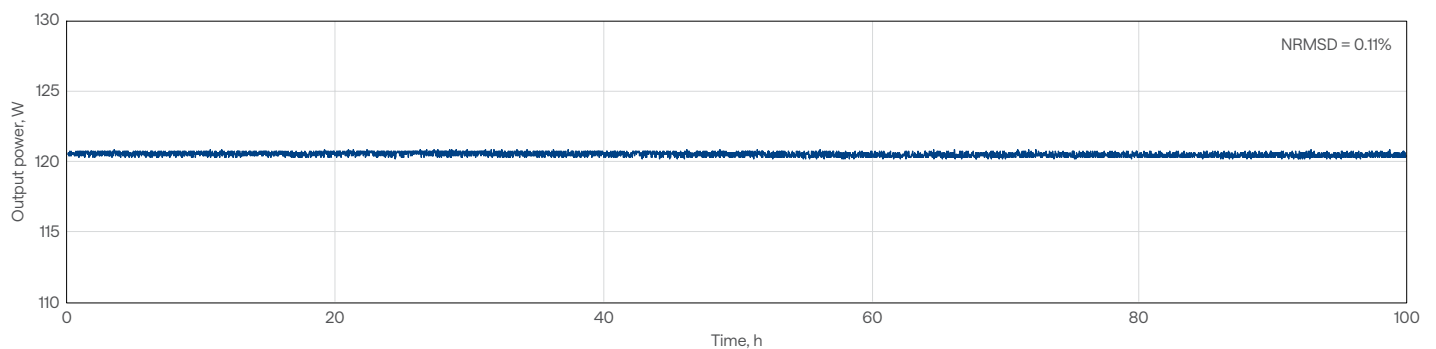
CARBIDE-CB3
Typical spectrum



CARBIDE-CB3
Typical beam profile



CARBIDE-CB3-120W
Long-term power stability





| | | | | | |
|-------|---------|---------|---------------|---------|----------|
| Model | CB3-20W | CB3-40W | CB3-40W-10MHz | CB3-80W | CB3-120W |
|-------|---------|---------|---------------|---------|----------|

OUTPUT CHARACTERISTICS

| | | | | | |
|---|--|--|--------------------------|------------------------|----------------|
| Cooling method | Water-cooled | | | | |
| Center wavelength | 1030 ± 10 nm | | | | |
| Maximum output power | 20 W | 40 W | | 80 W | 120 W |
| Pulse duration ¹⁾ | < 250 fs | | | < 350 fs ²⁾ | < 250 fs |
| Pulse duration tuning range | 250 fs – 10 ps | | | 350 fs – 10 ps | 250 fs – 10 ps |
| Maximum pulse energy | 0.4 mJ | | 0.2 mJ | 0.8 mJ | 2 mJ |
| Repetition rate | Single-shot – 1 MHz | Single-shot – 1 MHz (2 MHz on request) | Single-shot – 10 MHz | Single-shot – 2 MHz | |
| Pulse selection | Single-shot, pulse-on-demand, any fundamental repetition rate division | | | | |
| Polarization | Linear, vertical; 1: 1000 | | | | |
| Beam quality, M ² | < 1.2 | | | | |
| Beam diameter ³⁾ | 3.9 ± 0.4 mm | | | 4.2 ± 0.4 mm | 5.1 ± 0.7 mm |
| Beam pointing stability | < 20 µrad/°C | | | | |
| Pulse energy control | FEC ⁴⁾ | | Attenuator ⁵⁾ | FEC ⁴⁾ | |
| Pulse picker leakage | < 0.25% | | < 0.5% | < 0.25% | |
| Pulse-to-pulse energy stability, 12 h ⁶⁾ | < 0.5% | | | | |
| Long-term power stability, 100 h ⁶⁾ | < 0.5% | | | | |

MAIN OPTIONS

| | | | | | |
|--|--|--|--|--|--|
| Oscillator output ⁷⁾ | < 0.5 W, 120 – 250 fs, 1030 ± 10 nm, ≈ 65 MHz | | | | |
| Harmonic generator ⁸⁾ | 515 nm, 343 nm, 257 nm, or 206 nm; refer to CARBIDE HG | | | | |
| Optical parametric amplifier ⁹⁾ | UV – MIR; refer to I-OPA or ORPHEUS | | | | |
| BiBurst option | Tunable GHz and MHz burst with burst-in-burst capability; refer to BiBurst | | | | |

PHYSICAL DIMENSIONS

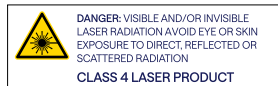
| | | | | | |
|----------------------------------|--------------------|--|--------------------|--|-------------------|
| Laser head (L × W × H) | 633 × 350 × 174 mm | | | | |
| Chiller (L × W × H) | 585 × 484 × 221 mm | | 680 × 484 × 307 mm | | |
| 24 V DC power supply (L × W × H) | 352 × 195 × 75 mm | | | | 376 × 449 × 88 mm |

ENVIRONMENTAL & UTILITY REQUIREMENTS

| | | | | | |
|-------------------------|------------------------|---|--|--|--|
| Operating temperature | 15 – 30 °C | | | | |
| Relative humidity | < 80% (non-condensing) | | | | |
| Electrical requirements | Laser | 100 V AC, 7 A – 240 V AC, 3 A; 50 – 60 Hz | 100 V AC, 12 A – 240 V AC, 5 A; 50 – 60 Hz | 100 V AC, 15 A – 240 V AC, 7 A; 50 – 60 Hz | |
| | Chiller | 100 – 230 V AC; 50 – 60 Hz | 200 – 230 V AC; 50 – 60 Hz | | |
| Rated power | Laser | 1000 W | 1000 W | 2000 W | |
| | Chiller | 1400 W | 2000 W | | |
| Power consumption | Laser | 500 W | 900 W | 1500 W | |
| | Chiller | 1000 W | 1300 W | 1800 W | |

¹⁾ Assuming a Gaussian pulse shape.
²⁾ Pulse duration can be reduced to < 250 fs if a pulse peak intensity of > 50 GW/cm² is tolerated by the customer setup.
³⁾ FW 1/e², using maximum pulse energy.
⁴⁾ Fast energy control (FEC) provides fast, full-scale individual pulse energy control; an external analog control input is available. An optional integrated waveplate-based variable optical attenuator is available.
⁵⁾ Waveplate-based variable optical attenuator (VOA); an external analog control input is available. FEC is available for repetition rates up to 2 MHz.

⁶⁾ Under stable environmental conditions. Expressed as normalized root mean squared deviation (NRMSD).
⁷⁾ Available simultaneously, requires a scientific interface. Contact sales@lightcon.com for more details or customized solutions.
⁸⁾ Integrated. For an external harmonic generator, refer to HIRO.
⁹⁾ Integrated. For more details and stand-alone OPAs, refer to wavelength-tunable sources.



CARBIDE-CB5 specifications

Air-cooled IR lasers

| Model | CB5-6W | CB5-5W | CB5-SP |
|-------|--------|--------|--------|
|-------|--------|--------|--------|

OUTPUT CHARACTERISTICS

| | | | |
|---|--|-------------------|--------------------------|
| Cooling method | Air-cooled ¹⁾ | | |
| Center wavelength | 1030 ± 10 nm | | |
| Maximum output power | 6 W | 5 W | |
| Pulse duration ²⁾ | < 290 fs | | < 190 fs |
| Pulse duration tuning range | 290 fs – 20 ps | | 190 fs – 20 ps |
| Maximum pulse energy | 100 µJ | 83 µJ | 100 µJ |
| Repetition rate | Single-shot – 1 MHz | | |
| Pulse selection | Single-shot, pulse-on-demand, any fundamental repetition rate division | | |
| Polarization | Linear, vertical; 1:1000 | | |
| Beam quality, M ² | < 1.2 | | |
| Beam diameter ³⁾ | 2.1 ± 0.4 mm | | |
| Beam pointing stability | < 20 µrad/°C | | |
| Pulse energy control | Attenuator ⁴⁾ | AOM ⁵⁾ | Attenuator ⁴⁾ |
| Pulse picker leakage | < 2% | < 0.1% | < 2% |
| Pulse-to-pulse energy stability, 12 h ⁶⁾ | < 0.5% | | |
| Long-term power stability, 100 h ⁶⁾ | < 0.5% | | |

MAIN OPTIONS

| | | | |
|--|--|--|--|
| Oscillator output | n/a | | |
| Harmonic generator ⁷⁾ | 515 nm, 343 nm, 257 nm, or 206 nm; refer to CARBIDE HG | | |
| Optical parametric amplifier ⁸⁾ | UV – MIR; refer to I-OPA or ORPHEUS | | |
| BiBurst option | n/a | | |

PHYSICAL DIMENSIONS

| | | | |
|----------------------------------|--------------------|--|--|
| Laser head (L × W × H) | 633 × 324 × 162 mm | | |
| Chiller | Not required | | |
| 24 V DC power supply (L × W × H) | 220 × 95 × 46 mm | | |

ENVIRONMENTAL & UTILITY REQUIREMENTS

| | | | |
|-------------------------|---|--|--|
| Operating temperature | 17 – 27 °C | | |
| Relative humidity | < 80% (non-condensing) | | |
| Electrical requirements | 100 V AC, 3 A – 240 V AC, 1.3 A; 50 – 60 Hz | | |
| Rated power | 280 W | | |
| Power consumption | 250 W | | |

¹⁾ Water-cooled version available on request.

²⁾ Assuming a Gaussian pulse shape.

³⁾ $FW 1/e^2$, using maximum pulse energy.

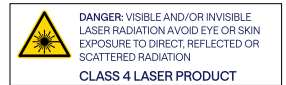
⁴⁾ Waveplate-based variable optical attenuator (VOA); an external analog control input is available.

⁵⁾ Enhanced contrast AOM. Provides fast, full-scale individual pulse energy control; an external analog control input is available.

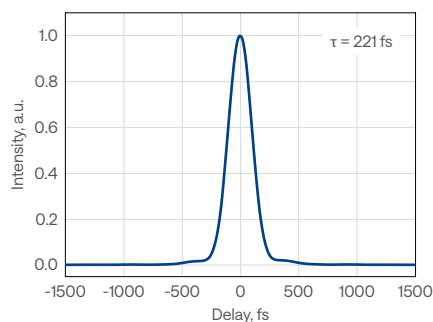
⁶⁾ Under stable environmental conditions. Expressed as normalized root mean squared deviation (NRMSD).

⁷⁾ Integrated. For an external harmonic generator, refer to HIRO.

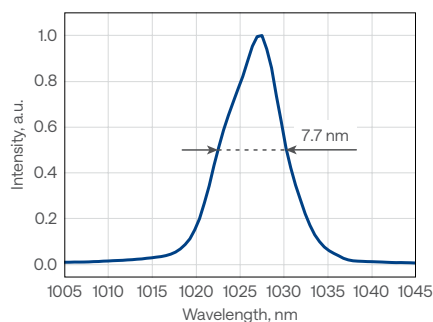
⁸⁾ Integrated. For more details and stand-alone OPAs, refer to wavelength-tunable sources.



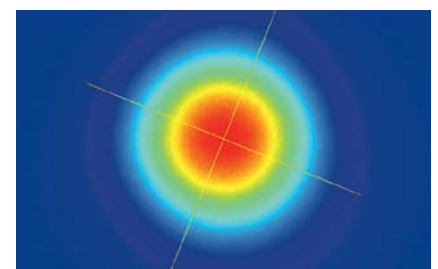
CARBIDE-CB5
Typical pulse duration



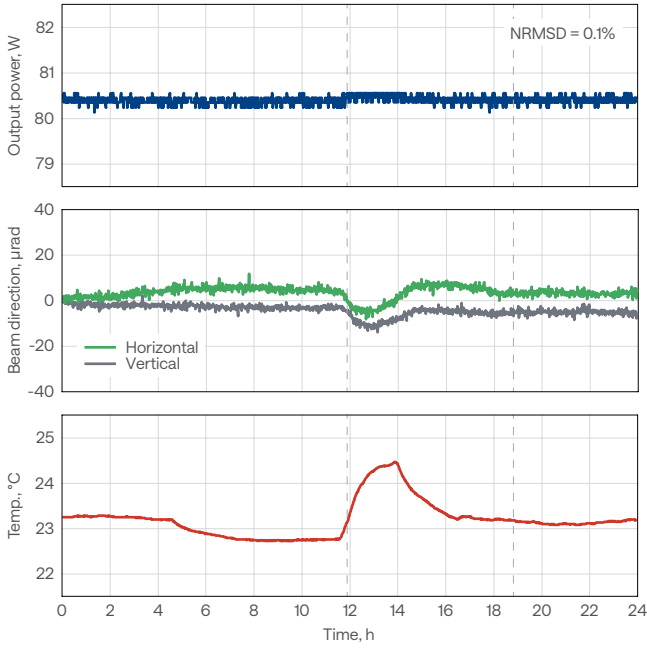
CARBIDE-CB5
Typical spectrum



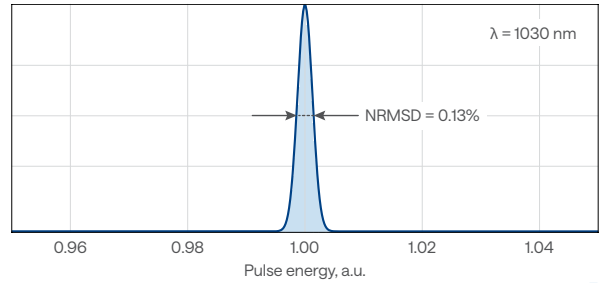
CARBIDE-CB5
Typical beam profile



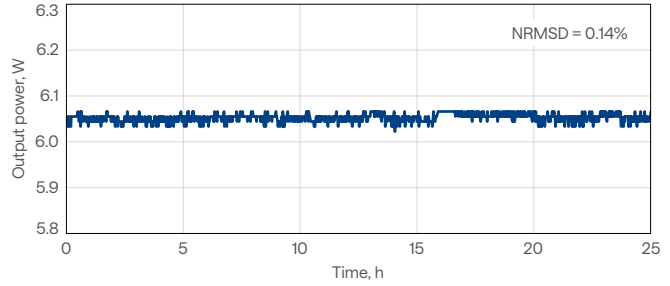
CARBIDE-CB3 output power and beam direction stability with power lock enabled, across varying environmental conditions



CARBIDE-CB3 Typical pulse-to-pulse energy stability

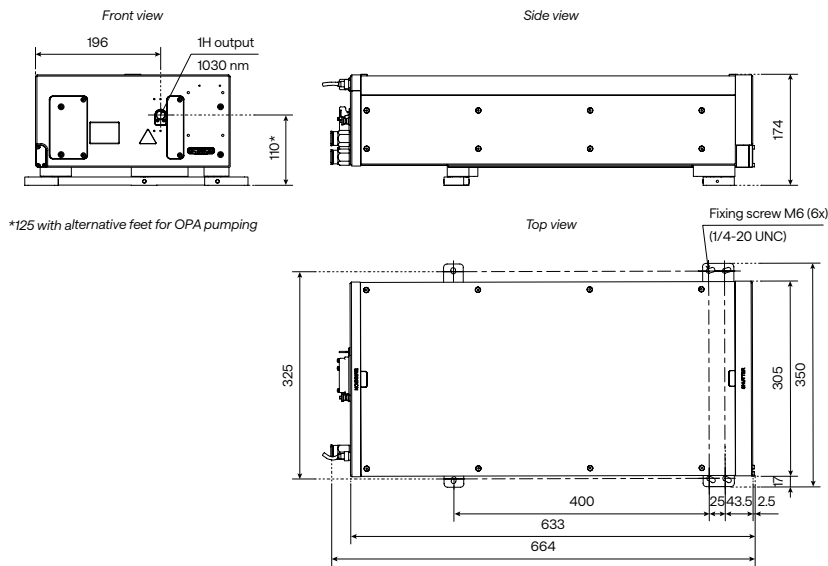


CARBIDE-CB5-6W Long-term power stability

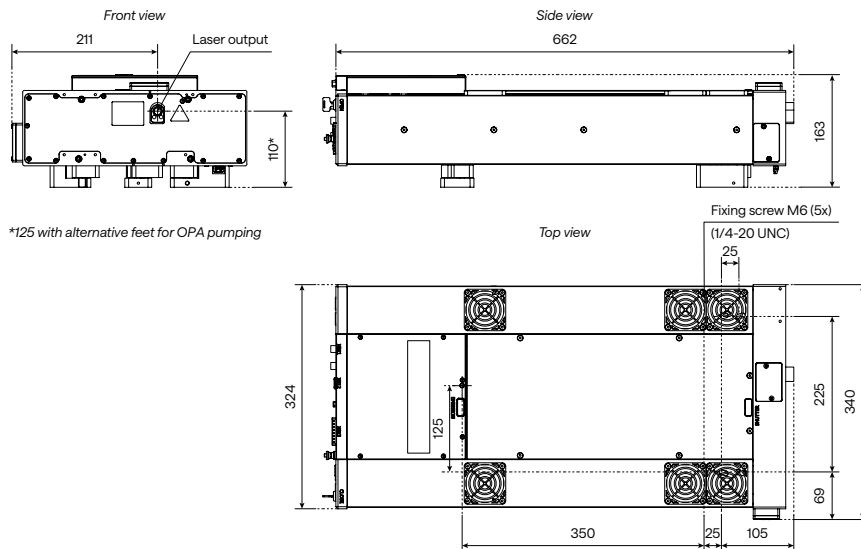


Drawings

CARBIDE-CB3



Air-cooled CARBIDE-CB5 with an attenuator



The drawings depend on the exact configuration. If crucial for integration, please contact sales@lightcon.com.



High-Energy Femtosecond Lasers

NEW

Maximum pulse energy of up to 5 mJ

Down to < 100 fs right at the output

Tunable pulse duration, 100 fs – 20 ps

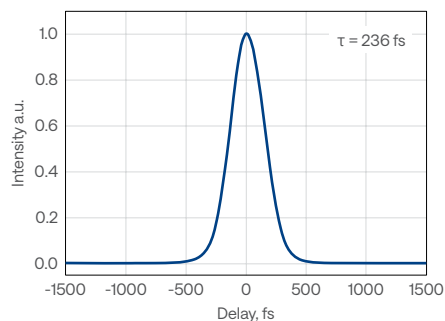
Pulse-on-demand and BiBurst for pulse control

Automated harmonics up to the 5th and wavelength-tunable extensions



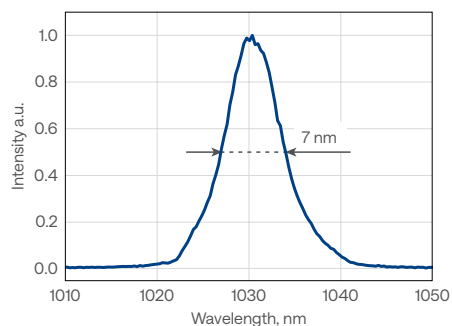
PHAROS-PH2-5mJ

Typical pulse duration



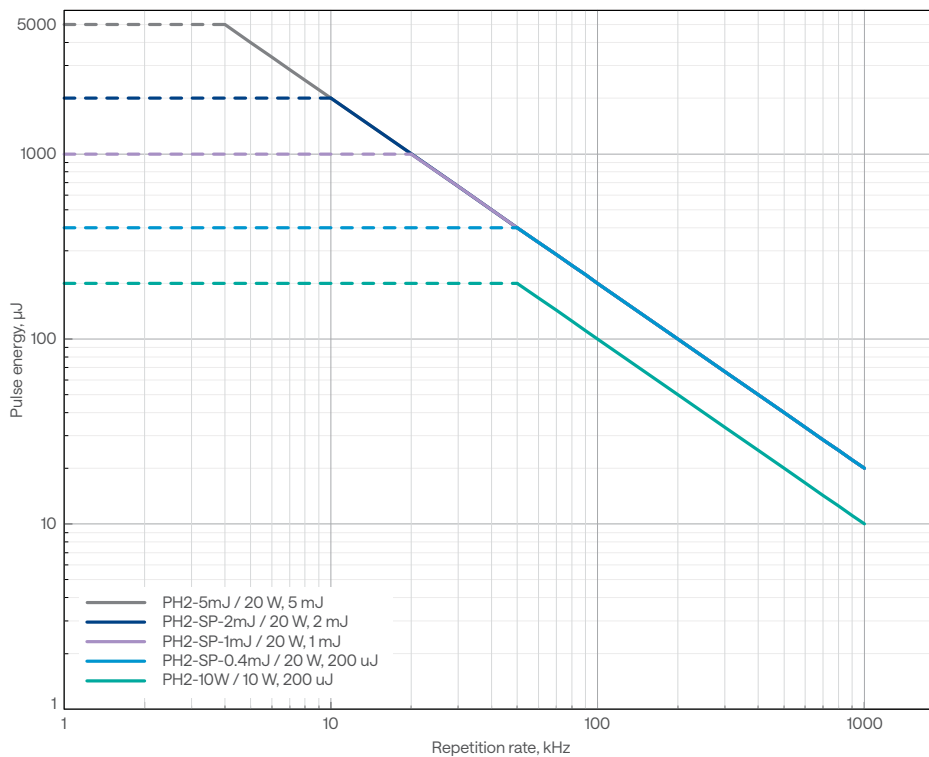
PHAROS-PH2-5mJ

Typical spectrum



PHAROS

Pulse energy vs fundamental repetition rate



Specifications

NEW

| Model | PH2-10W | PH2-SP | | | PH2-5mJ | PH2-UP | |
|-------|---------|--------|--|--|---------|--------|--|
|-------|---------|--------|--|--|---------|--------|--|

OUTPUT CHARACTERISTICS

| | | | | | | | |
|---|--|--------------|--------------------------------------|--------------|-------------|--------------|----------------|
| Center wavelength ¹⁾ | 1030 ± 10 nm | | | | | | |
| Maximum output power | 10 W | | 20 W | | | | |
| Pulse duration ²⁾ | < 290 fs | | < 190 fs | | < 250 fs | | < 100 fs |
| Pulse duration tuning range | 290 fs – 10 ps (20 ps on request) | | 190 fs – 10 ps (20 ps on request) | | n/a | | 100 fs – 10 ps |
| Maximum pulse energy | 0.2 mJ | 0.4 mJ | 1 mJ | 2 mJ | 5 mJ | 0.4 mJ | 1 mJ |
| Repetition rate | Single-shot – 1 MHz | | | | | | |
| Pulse selection | Single-shot, pulse-on-demand, any fundamental repetition rate division | | | | | | |
| Polarization | Linear, horizontal | | | | | | |
| Beam quality, M ² | < 1.2 | | < 1.3 | | | < 1.2 | |
| Beam diameter ³⁾ | 3.3 ± 0.5 mm | 4.0 ± 0.5 mm | 4.5 ± 0.5 mm | 6.8 ± 0.7 mm | 11 ± 0.5 mm | 4.5 ± 0.5 mm | 6 ± 0.5 mm |
| Beam pointing stability | < 20 µrad/°C | | | | | | |
| Pre-pulse contrast | < 1 : 1000 | | | | | | |
| Post-pulse contrast | < 1 : 200 | | | | | | |
| Pulse-to-pulse energy stability, 12 h ⁴⁾ | < 0.5% | | | | | | |
| Long-term power stability, 100 h ⁴⁾ | < 0.5% | | | | | | |

MAIN OPTIONS

| | | | | | | | |
|--|--|--|--|--|--|--|--|
| Oscillator output ⁵⁾ | 1 – 7 W, 50 – 250 fs, ≈ 1035 nm, ≈ 76 MHz | | | | | | |
| Harmonic generator ⁶⁾ | 515 nm, 343 nm, 257 nm, or 206 nm; refer to PHAROS HG or HIRO | | | | | | |
| Optical parametric amplifier ⁷⁾ | UV – MIR; refer to I-OPA or ORPHEUS | | | | | | |
| BiBurst option | Tunable GHz and MHz burst with burst-in-burst capability; refer to BiBurst | | | | | | |
| CEP stabilization | Refer to CEP & RRL Option | | | | | | |
| Repetition rate locking | | | | | | | |

PHYSICAL DIMENSIONS

| | | | |
|--|--------------------|--------------------|--------------------|
| Laser head (L × W × H) ⁸⁾ | 730 × 419 × 230 mm | 827 × 492 × 250 mm | 770 × 419 × 230 mm |
| Chiller (L × W × H) | 590 × 484 × 267 mm | | |
| 24 V DC power supply (L × W × H) ⁸⁾ | 280 × 144 × 49 mm | | |

ENVIRONMENTAL & UTILITY REQUIREMENTS

| | | | |
|-------------------------|---|--|--|
| Operating temperature | 15 – 30 °C (air conditioning recommended) | | |
| Relative humidity | < 80% (non-condensing) | | |
| Electrical requirements | Laser | 100 V AC, 12 A – 240 V AC; 5 A, 50 – 60 Hz | |
| | Chiller | 100 – 230 V AC; 50 – 60 Hz | |
| Rated power | Laser | 1000 W | |
| | Chiller | 1400 W | |
| Power consumption | Laser | 600 W | |
| | Chiller | 1000 W | |

¹⁾ Precise wavelengths for specific models are available upon request.

²⁾ Assuming a Gaussian pulse shape.

³⁾ FW 1/e², measured at laser output, using maximum pulse energy.

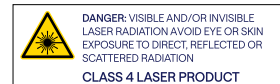
⁴⁾ Under stable environmental conditions. Expressed as normalized root mean squared deviation (NRMSD).

⁵⁾ Available simultaneously. Contact sales@lightcon.com for more details or customized solutions.

⁶⁾ Integrated except for PH2-5mJ. For an external harmonic generator, refer to HIRO.

⁷⁾ Integrated except for PH2-5mJ. For more options and OPAs for -5mJ and -UP models, refer to the ORPHEUS series of OPAs.

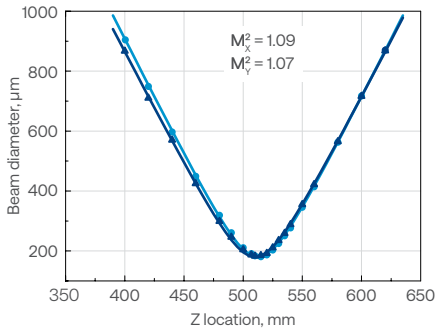
⁸⁾ Dimensions depend on the laser configuration and integrated options.



Beam properties

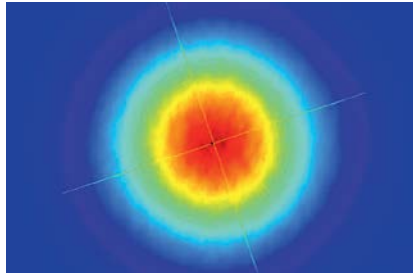
PHAROS

Typical M^2 measurement data



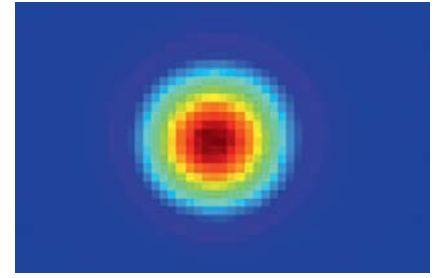
PHAROS

Typical near-field beam profile



PHAROS

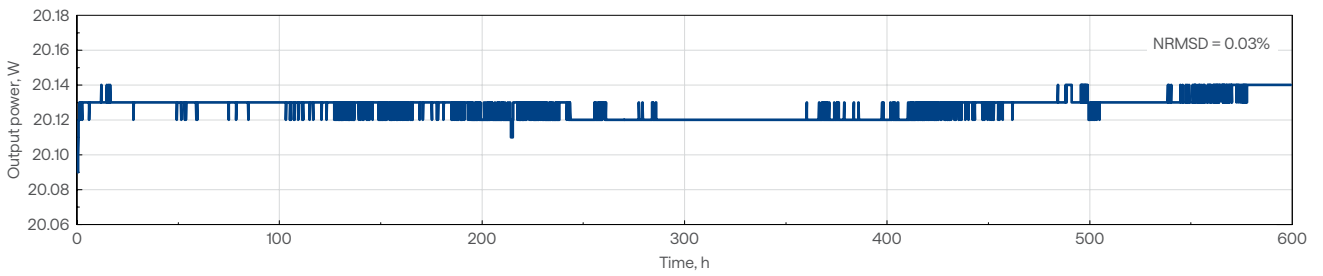
Typical far-field beam profile



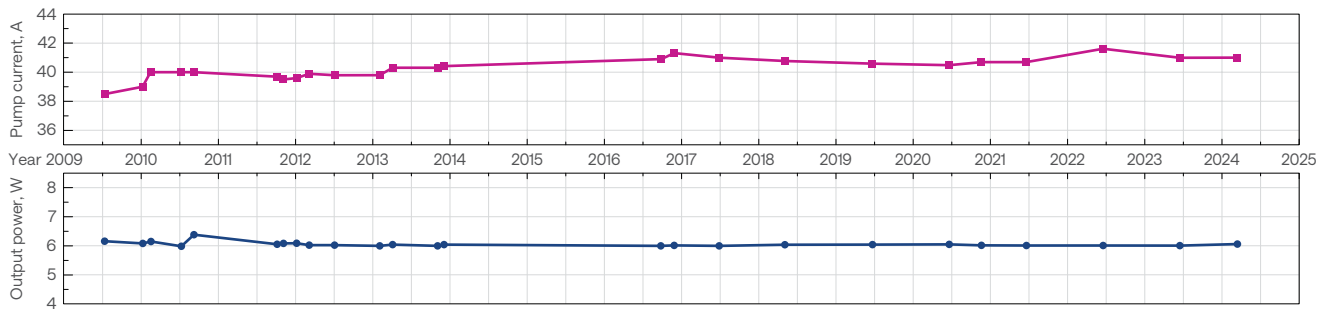
Stability measurements

PHAROS

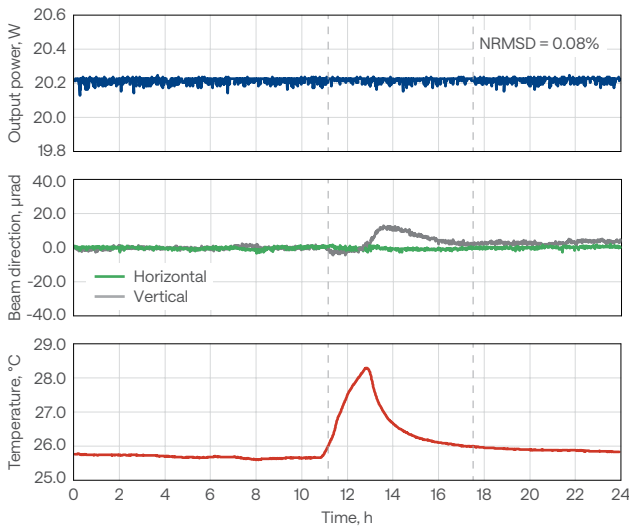
Long-term power stability



Output power of industrial-grade PHAROS lasers operating 24/7 and the current of the pump diodes over the years

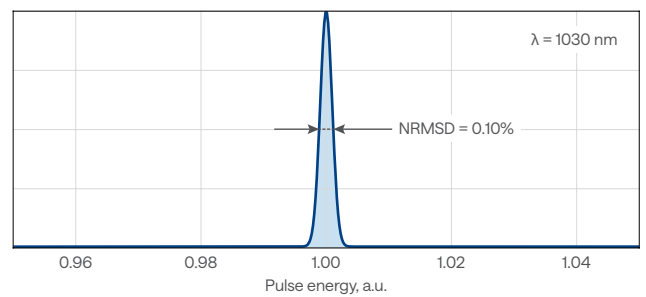


PHAROS output power and beam pointing stability with power lock enabled, across varying environmental conditions



PHAROS

Typical pulse-to-pulse energy stability



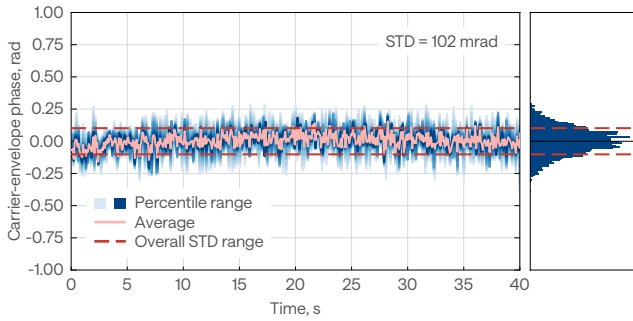
CEP stabilization

PHAROS lasers can be equipped with feedback electronics for carrier-envelope phase (CEP) stabilization of the output pulses. The carrier-envelope offset (CEO) of the PHAROS oscillator is actively locked to 1/4th of the repetition rate with a < 100 mrad standard deviation. The CEP stable pulses from the synchronized amplifier

have a < 350 mrad standard deviation. The CEP drift occurring inside the amplifier and the user's setup can be compensated with an out of loop f-2f interferometer, which is a part of the complete PHAROS active CEP stabilization package.

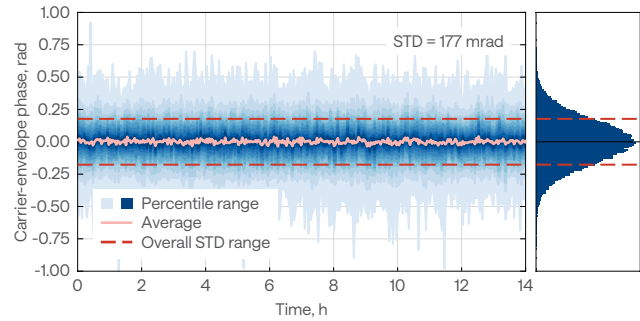
PHAROS

Short-term CEP stability operating at 200 kHz repetition rate



PHAROS

Long-term CEP stability operating at 200 kHz repetition rate

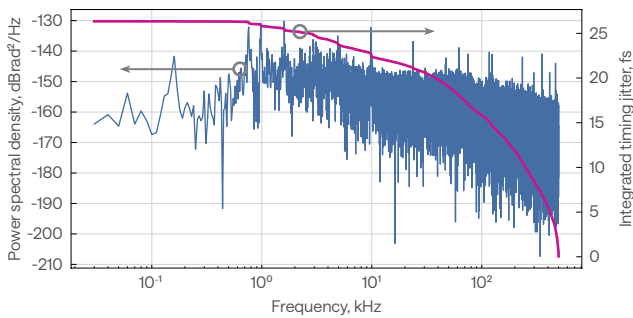


Repetition rate locking

The oscillators in PHAROS lasers can be customized for repetition rate locking applications. Coupled with the necessary feedback electronics, the oscillator's repetition rate can be synchronized to an external RF source using the two piezo stages installed within the cavity.

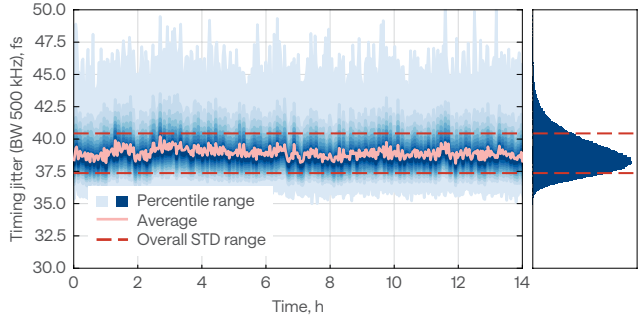
The repetition rate locking system ensures an integrated timing jitter of less than 200 fs for RF reference frequencies above 500 MHz. Additionally, continuous phase shifting is available upon request.

Phase noise data of PHAROS oscillator locked to a 2.8 GHz RF source



Timing jitter stability over 14 h

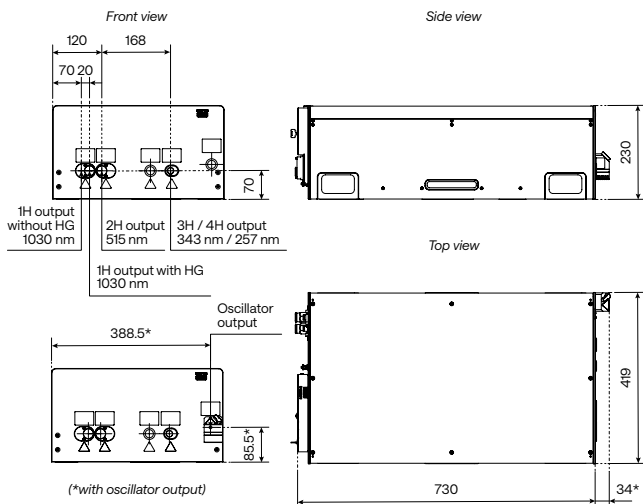
PHAROS oscillator locked to a 2.8 GHz RF source



Drawings

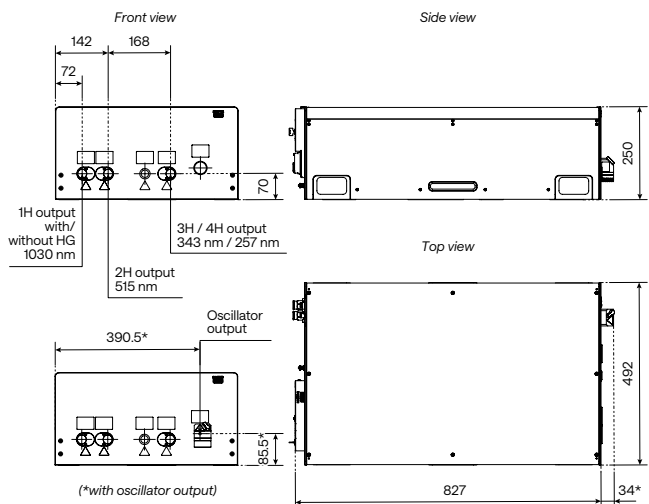
PHAROS-PH2-730

-10W or -20W-SP with a FEC or BiBurst option, or a harmonic generator



PHAROS-PH2-827

-10W with an -HE harmonic generator option, or -5mJ



The drawings depend on the exact configuration. If crucial for integration, please contact sales@lightcon.com.



Global Representative Network

| | | | |
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